

## **Supplementary information**

### **The electronic effect on the electrocatalytic hydrogen evolution reaction of silicon(IV) corrole complexes**

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## 1. General informations

All reagents were purchased commercially and were used without further purification unless otherwise pointed out.  $^1\text{H}$  and  $^{19}\text{F}$  NMR spectra were recorded on a Bruker Avance III 500 MHz NMR spectrometer. The NMR spectra were referenced to the  $\text{CDCl}_3$  residual solvent signal (7.26 ppm). UV-vis spectra in  $\text{CH}_2\text{Cl}_2$  were recorded using a Hitachi U-3010 spectrophotometer at room temperature. High-resolution mass spectra (HRMS) were obtained using the Bruker microQ-TOF-QII high resolution spectrometer in the electrospray ionization (ESI) mode using Bruker Daltonics coupled to a Water Acquity system. X-ray photoelectron spectroscopy (XPS) was measured using an Axis Ultra DLD spectrophotometer, correcting the binding energies by comparing to C 1s peak (284.8 eV) by the adventitious hydrocarbon. Electrochemical measurements were performed with a CHI-660E electrochemical workstation at room temperature under saturated  $\text{N}_2$ . The three-electrode cell had glass carbon (GC) as the working electrode, graphite rod as the counter electrode, saturated  $\text{Ag}/\text{AgNO}_3$  as the reference electrode in DMF, and  $\text{Ag}/\text{AgCl}$  as the reference electrode in aqueous solutions. Ferrocene was added as an internal standard in DMF. Controlled potential electrolysis (CPE) test was performed in a single electrolytic cell filled with 20 mL of buffer solution ( $\text{CH}_3\text{CN}:\text{H}_2\text{O}$  1:2) with 0.1 M KCl and 0.25 M  $\text{KH}_2\text{PO}_4$ .

## 2. Synthesis of corroles

5,10,15-tris (pentafluorophenyl) corrole (**F<sub>15</sub>C**), 5,15-bis (pentafluorophenyl)-10-(phen-yl) corrole (**F<sub>10</sub>C**), 5,15-bis (phenyl)-10-(pentafluorophenyl) corrole (**F<sub>5</sub>C**), 5,10,15-tris (phe-nyl) corrole (**F<sub>0</sub>C**) were prepared by previously published procedures.<sup>1-3</sup>

### 5,10,15-tris (pentafluorophenyl) corrole (**F<sub>15</sub>C**)

$^1\text{H}$  NMR (500 MHz, Chloroform-*d*)  $\delta$  9.10 (d,  $J$  = 4.2 Hz, 2H), 8.78 (d,  $J$  = 4.6 Hz, 2H), 8.58 (dd,  $J$  = 21.0, 3.8 Hz, 4H).  $^{19}\text{F}$  NMR (471 MHz, Chloroform-*d*)  $\delta$  -137.45 (d,  $J$  = 257.0 Hz, 6F), -152.43 (d,  $J$  = 272.7 Hz, 3F), -161.62 (d,  $J$  = 219.8 Hz, 6F). HR-MS:  $m/z$  calculated for  $\text{C}_{37}\text{H}_{12}\text{F}_{15}\text{N}_4^+$ : 797.0817  $[\text{M}+\text{H}]^+$ ; found: 797.0824.

### 5,15-bis (pentafluorophenyl)-10-(phenyl) corrole (**F<sub>10</sub>C**)

$^1\text{H}$  NMR (500 MHz, Chloroform-*d*)  $\delta$  9.11 (d,  $J$  = 4.3 Hz, 2H), 8.71 (s, 4H), 8.57 (d,  $J$  = 4.3 Hz, 2H), 8.18 (d,  $J$  = 3.6 Hz, 2H), 7.80 – 7.74 (m, 3H).  $^{19}\text{F}$  NMR (471 MHz, Methylene Chloride-*d*<sub>2</sub>)  $\delta$  -139.77 (dd,  $J$  = 24.3, 8.5 Hz, 4F), -154.77 (d,  $J$  = 20.7 Hz, 2F), -163.45 – -164.07 (m, 4F). HR-MS:  $m/z$  calculated for  $\text{C}_{37}\text{H}_{17}\text{F}_{10}\text{N}_4^+$ : 707.1288  $[\text{M}+\text{H}]^+$ ; found: 707.1293.

### 5,15-bis (phenyl)-10-(pentafluorophenyl) corrole (**F<sub>5</sub>C**)

$^1\text{H}$  NMR (500 MHz, Chloroform-*d*)  $\delta$  8.91 (d,  $J$  = 60.5 Hz, 4H), 8.57 – 8.28 (m, 8H), 7.83 (d,  $J$  = 27.3 Hz, 6H).  $^{19}\text{F}$  NMR (471 MHz, Chloroform-*d*)  $\delta$  -136.85 – -138.44 (m, 2F), -153.76 (d,  $J$  = 128.5 Hz, 1F), -162.30 (d,  $J$  = 129.3 Hz, 2F). HR-MS:  $m/z$  calculated for  $\text{C}_{37}\text{H}_{22}\text{F}_5\text{N}_4^+$ : 617.1759  $[\text{M}+\text{H}]^+$ ; found: 617.1763.

### 5,10,15-tris (phenyl) corrole ( $F_0C$ )

$^1H$  NMR (500 MHz, Chloroform- $d$ )  $\delta$  8.98 – 8.81 (m, 4H), 8.65 – 8.10 (m, 10H), 7.93 – 7.64 (m, 9H). HR-MS:  $m/z$  calculated for  $C_{37}H_{27}N_4^+$ : 527.2230  $[M+H]^+$ ; found: 527.2227.

### 5,10,15-tris (pentafluorophenyl) silicon (IV) corrole ( $F_{15}C-Si$ )

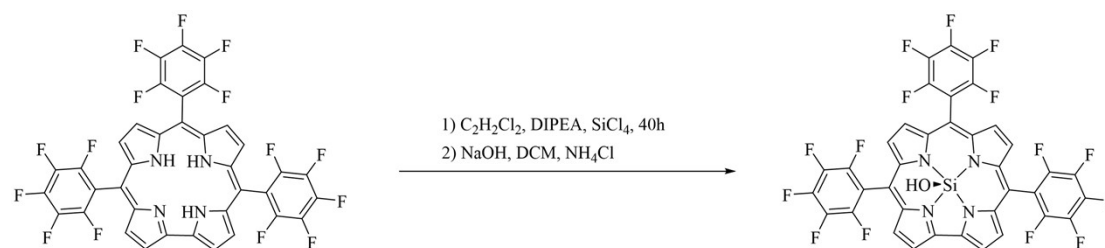


Fig. S1 Synthetic routes of Si corrole.

The synthesis method of silicon corrole complexes was thoroughly detailed in previous reports,<sup>4</sup> and our research has made some modifications to it. Taking the synthesis of  $F_{15}C-Si$  as an example: Free base  $F_{15}C$  (199 mg, 0.25 mmol) was dissolved in 1,2-dichloroethane (38 mL) and DIPEA (N, N-diisopropylethylamine, 6.5 mL, 38 mmol). Tetrachlorosilane (1.4 mL, 12.5 mmol) was slowly added to the obtained solution. The reaction mixture was stirred at 60 °C for 40 hours. The reaction mixture was then washed with aqueous NaOH (1 M) and extracted with dichloromethane. The organic extract was neutralized with an aqueous solution of  $NH_4Cl$  and washed with saturated saline. The organic extract was dried with anhydrous  $Na_2SO_4$  and after removing the solvent under reduced pressure, the crude product was purified by silica gel chromatography column by using a solvent system ( $V_{DCM}: V_{Hex} = 4:1$ ) as eluent. After recrystallization obtain black solid (171.1 mg, yield 81.7%).  $^1H$  NMR (500 MHz, Chloroform- $d$ )  $\delta$  9.54 (d,  $J = 4.4$  Hz, 2H), 9.11 (d,  $J = 4.9$  Hz, 2H), 9.07 (d,  $J = 4.4$  Hz, 2H), 8.93 (d,  $J = 4.8$  Hz, 2H).  $^{19}F$  NMR (471 MHz, Chloroform- $d$ )  $\delta$  -136.30 – -136.53 (m, 3F), -137.08 – -137.26 (m, 3F), -151.74 – -152.01 (m, 3F), -161.01 – -161.46 (m, 6F).  $^{29}Si$  NMR (119 MHz,  $CDCl_3$ )  $\delta$  -149.4. HR-MS:  $m/z$  calculated for  $C_{37}H_9F_{15}N_4NaOSi^+$ : 861.0198  $[M+Na]^+$ ; found: 861.0204.

### 5,15-bis (pentafluorophenyl)-10-(phenyl) silicon (IV) corrole ( $F_{10}C-Si$ )

The synthetic route was similar to  $F_{15}C-Si$ , after recrystallization obtain pure silicon corrole (black solid, yield 80.3%).  $^1H$  NMR (500 MHz, Chloroform- $d$ )  $\delta$  9.52 (d,  $J = 4.3$  Hz, 2H), 9.03 (dt,  $J = 6.0, 4.6$  Hz, 6H), 8.33 – 8.28 (m, 1H), 8.09 – 8.04 (m, 1H), 7.85 – 7.74 (m, 3H).  $^{19}F$  NMR (471 MHz, Chloroform- $d$ )  $\delta$  -136.44 – -136.56 (m, 2F), -137.27 – -137.39 (m, 2F), -152.43 (t,  $J = 20.9$  Hz, 2F), -161.36 – -161.65 (m, 4F).  $^{29}Si$  NMR (119 MHz,  $CDCl_3$ )  $\delta$  -149.2. HR-MS:  $m/z$  calculated for  $C_{37}H_{15}F_{10}N_4OSi^+$ : 749.0850  $[M+H]^+$ ; found: 749.0857.

### **5,15-bis (phenyl)-10-(pentafluorophenyl) silicon (IV) corrole ( $F_5C-Si$ )**

The synthetic route was similar to  $F_{15}C-Si$ , after recrystallization obtain pure silicon corrole (black solid, yield 77.6%).  $^1H$  NMR (500 MHz, Chloroform-*d*)  $\delta$  9.28 (d,  $J = 3.4$  Hz, 2H), 9.16 (d,  $J = 3.9$  Hz, 2H), 8.99 (d,  $J = 3.4$  Hz, 2H), 8.65 (d,  $J = 3.9$  Hz, 2H), 8.30 – 8.05 (m, 4H), 7.70 (t,  $J = 7.2$  Hz, 6H).  $^{19}F$  NMR (471 MHz, Chloroform-*d*)  $\delta$  -136.68 (dd,  $J = 24.4, 8.5$  Hz, 1F), -137.51 (dd,  $J = 24.1, 8.6$  Hz, 1F), -153.02 (t, 1F), -161.83 (dtd,  $J = 88.1, 22.6, 21.7, 8.4$  Hz, 2F).  $^{29}Si$  NMR (119 MHz,  $CDCl_3$ )  $\delta$  -148.7. HR-MS:  $m/z$  calculated for  $C_{37}H_{20}F_5N_4OSi^+$ : 659.1321  $[M+H]^+$ ; found: 659.1321.

### **5,10,15-tris (phenyl) silicon (IV) corrole ( $F_0C-Si$ )**

The synthetic route was similar to  $F_{15}C-Si$ , after recrystallization obtain pure silicon corrole (black solid, yield 71.5%).  $^1H$  NMR (500 MHz, Chloroform-*d*)  $\delta$  9.37 (d,  $J = 4.3$  Hz, 2H), 9.21 (d,  $J = 4.8$  Hz, 2H), 9.08 (d,  $J = 4.2$  Hz, 2H), 8.91 (d,  $J = 4.8$  Hz, 2H), 8.41 – 8.17 (m, 4H), 8.05 (d,  $J = 6.9$  Hz, 1H), 7.86 – 7.70 (m, 10H).  $^{29}Si$  NMR (119 MHz,  $CDCl_3$ )  $\delta$  -148.7. HR-MS:  $m/z$  calculated for  $C_{37}H_{24}N_4NaOSi^+$ : 591.1612  $[M+Na]^+$ ; found: 591.1616.

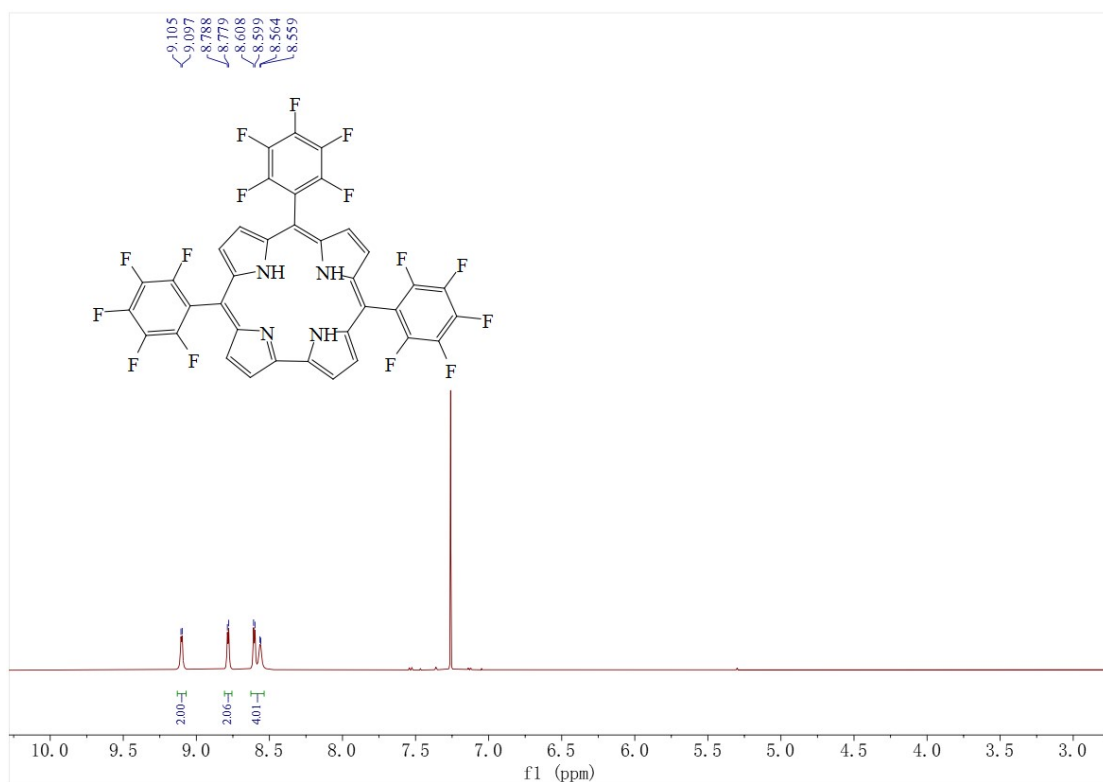


Fig. S2 <sup>1</sup>H NMR spectrum of F<sub>15</sub>C.

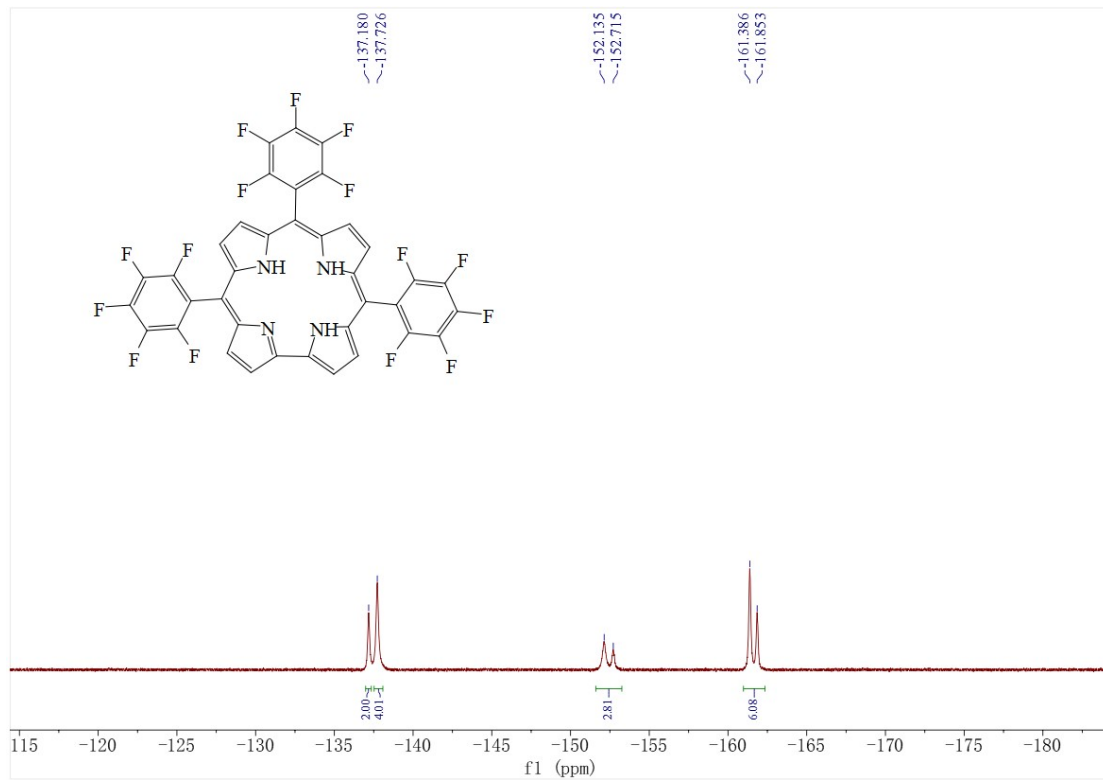
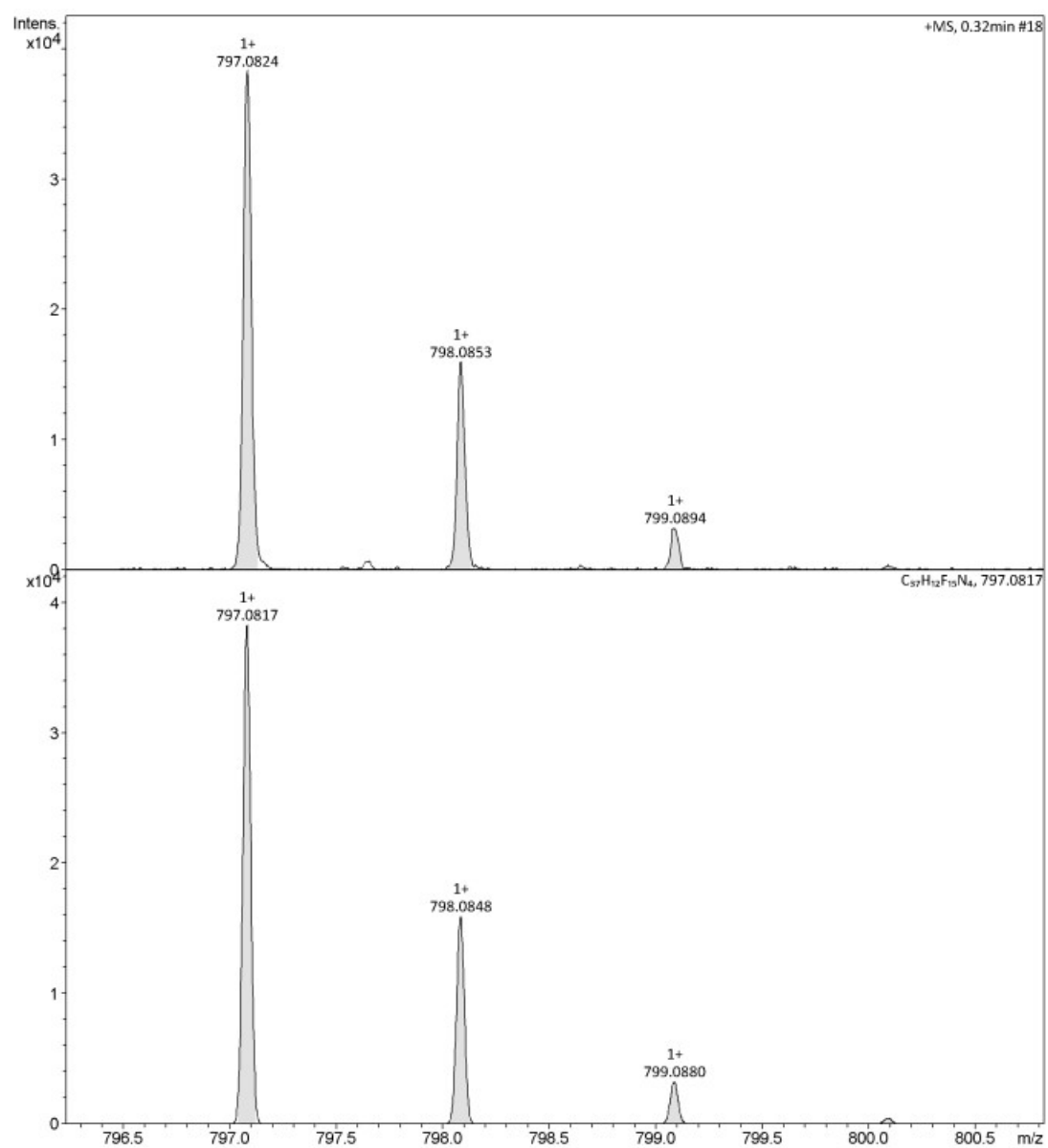


Fig. S3 <sup>19</sup>F NMR spectrum of F<sub>15</sub>C.



**Fig. S4** ESI-HRMS spectrum of  $F_{15}C$ .

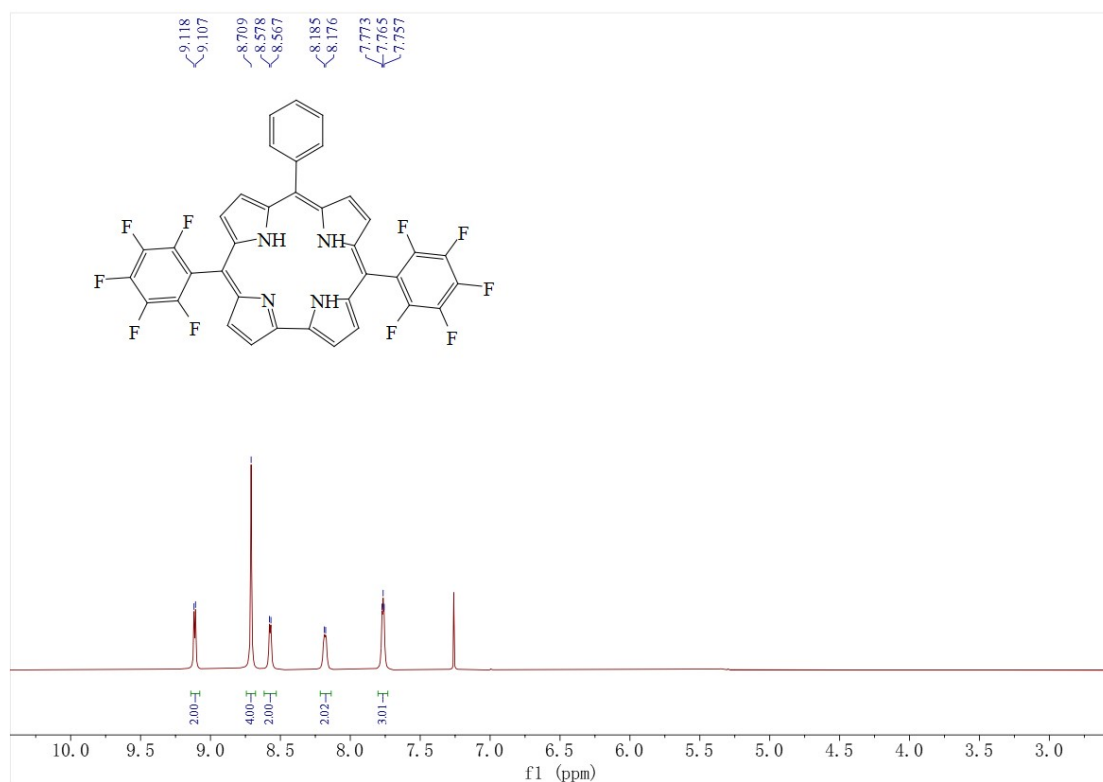


Fig. S5 <sup>1</sup>H NMR spectrum of F<sub>10</sub>C.

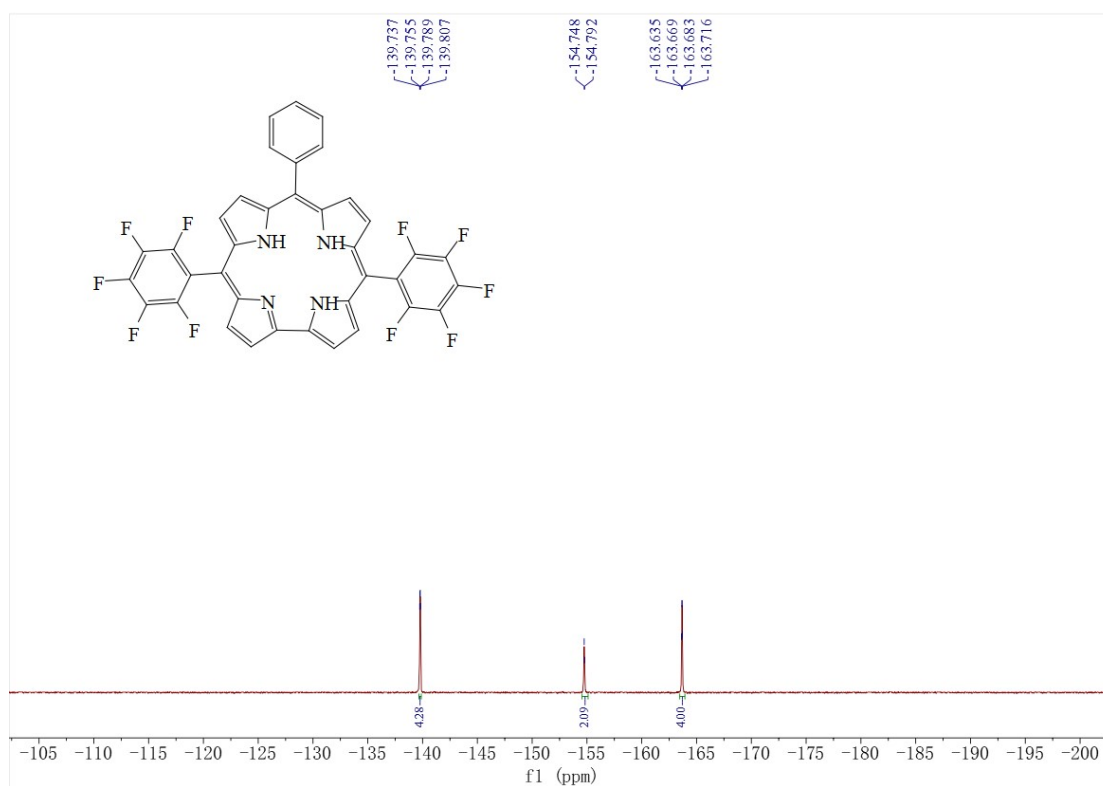
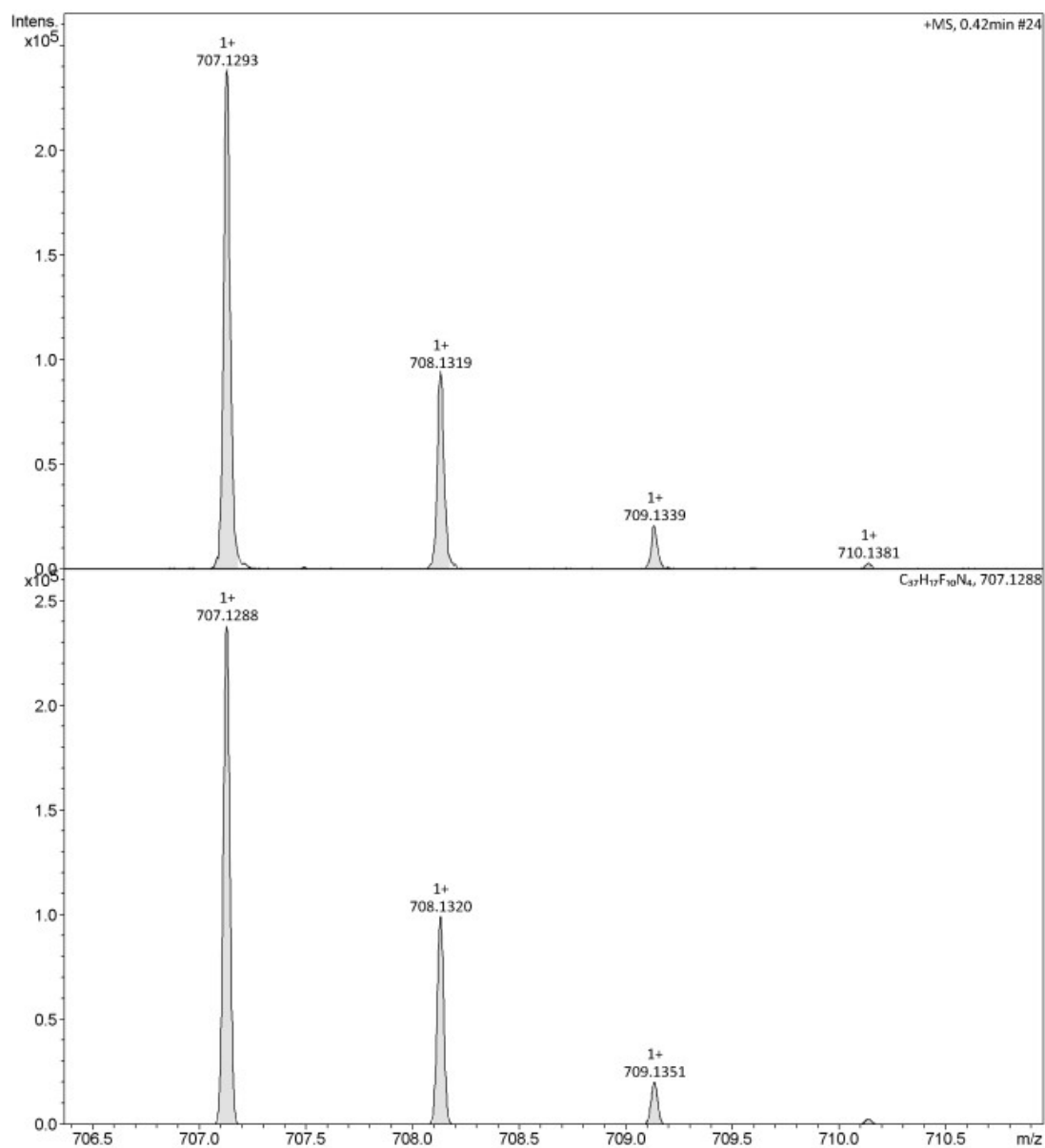
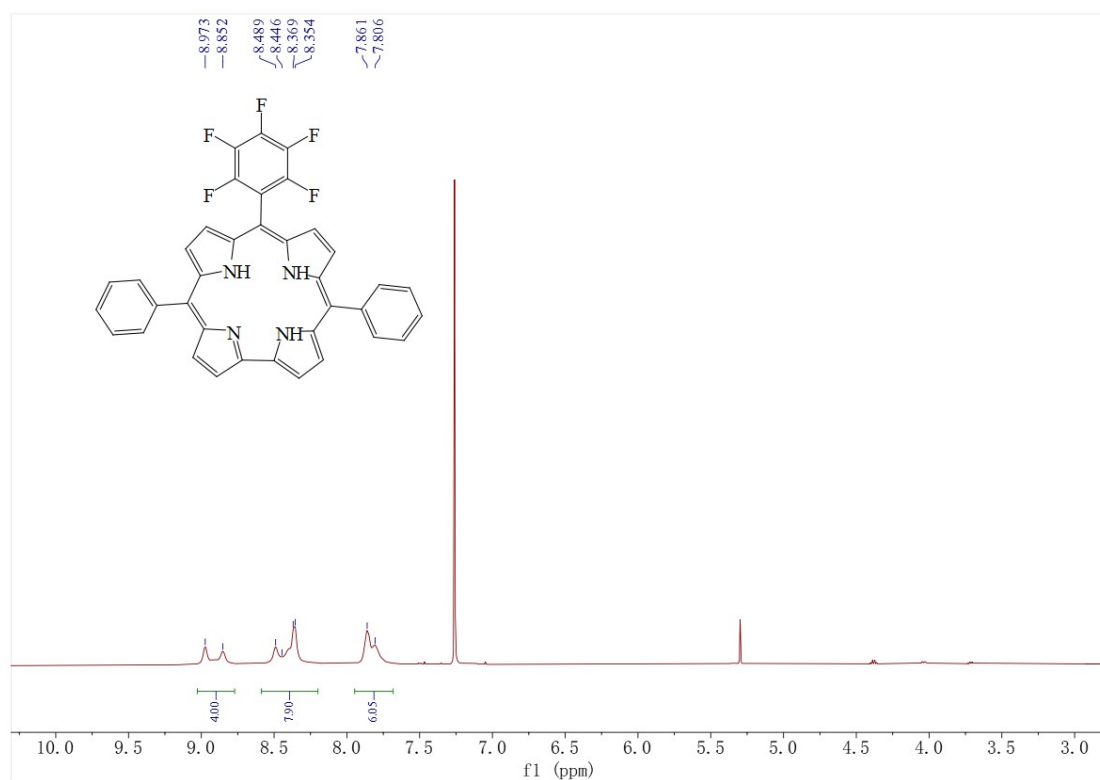


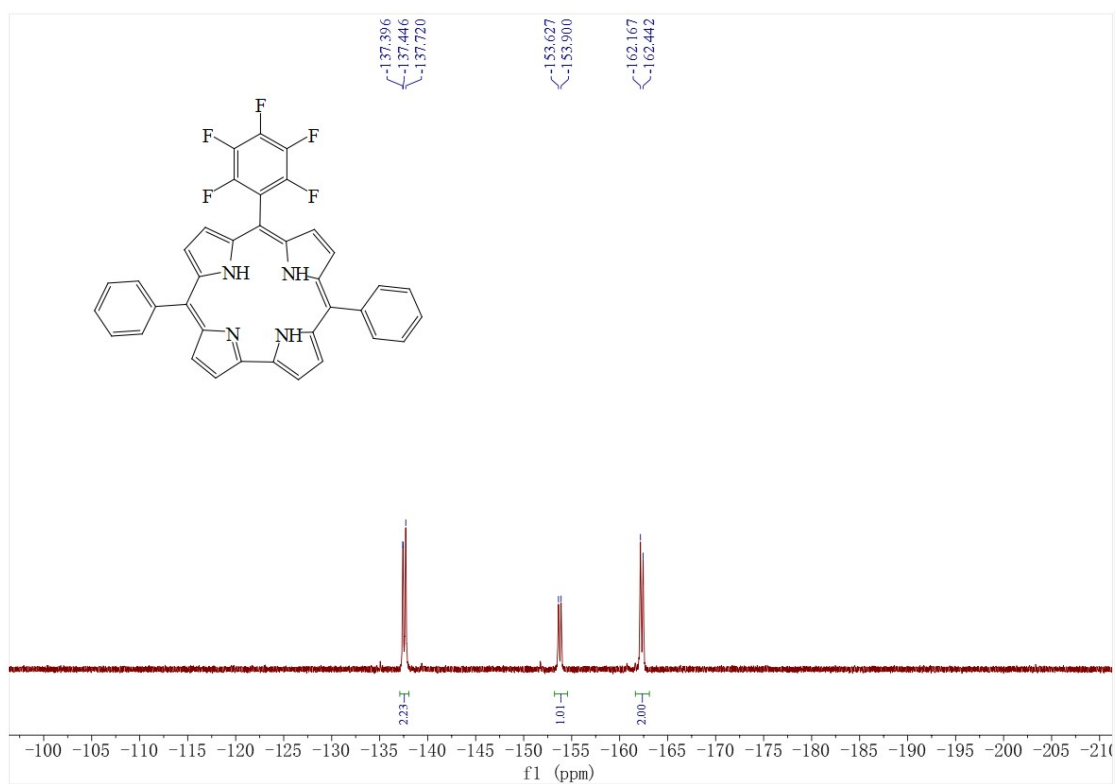
Fig. S6 <sup>19</sup>F NMR spectrum of F<sub>10</sub>C.



**Fig. S7** ESI-HRMS spectrum of F<sub>10</sub>C.



**Fig. S8** <sup>1</sup>H NMR spectrum of **F<sub>5</sub>C**.



**Fig. S9** <sup>19</sup>F NMR spectrum of **F<sub>5</sub>C**.

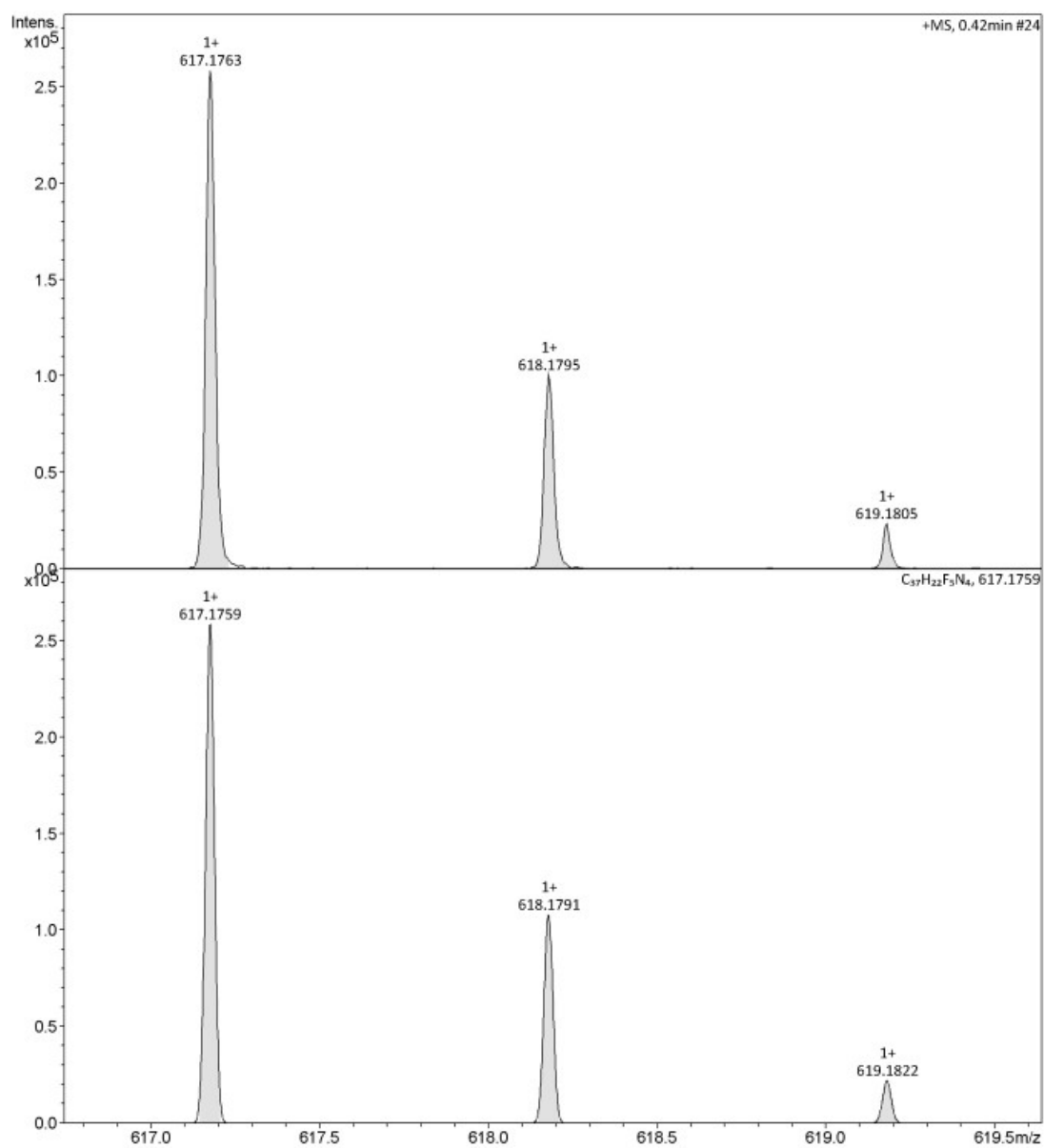
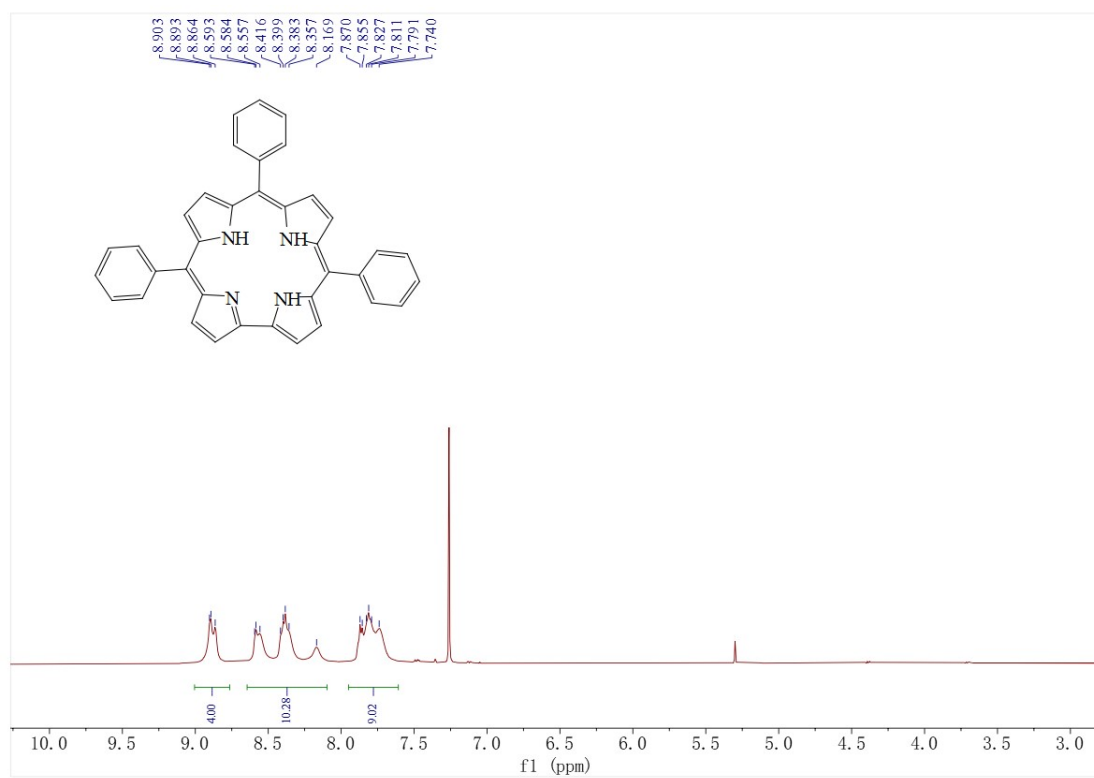


Fig. S10 ESI-HRMS spectrum of F<sub>5</sub>C.



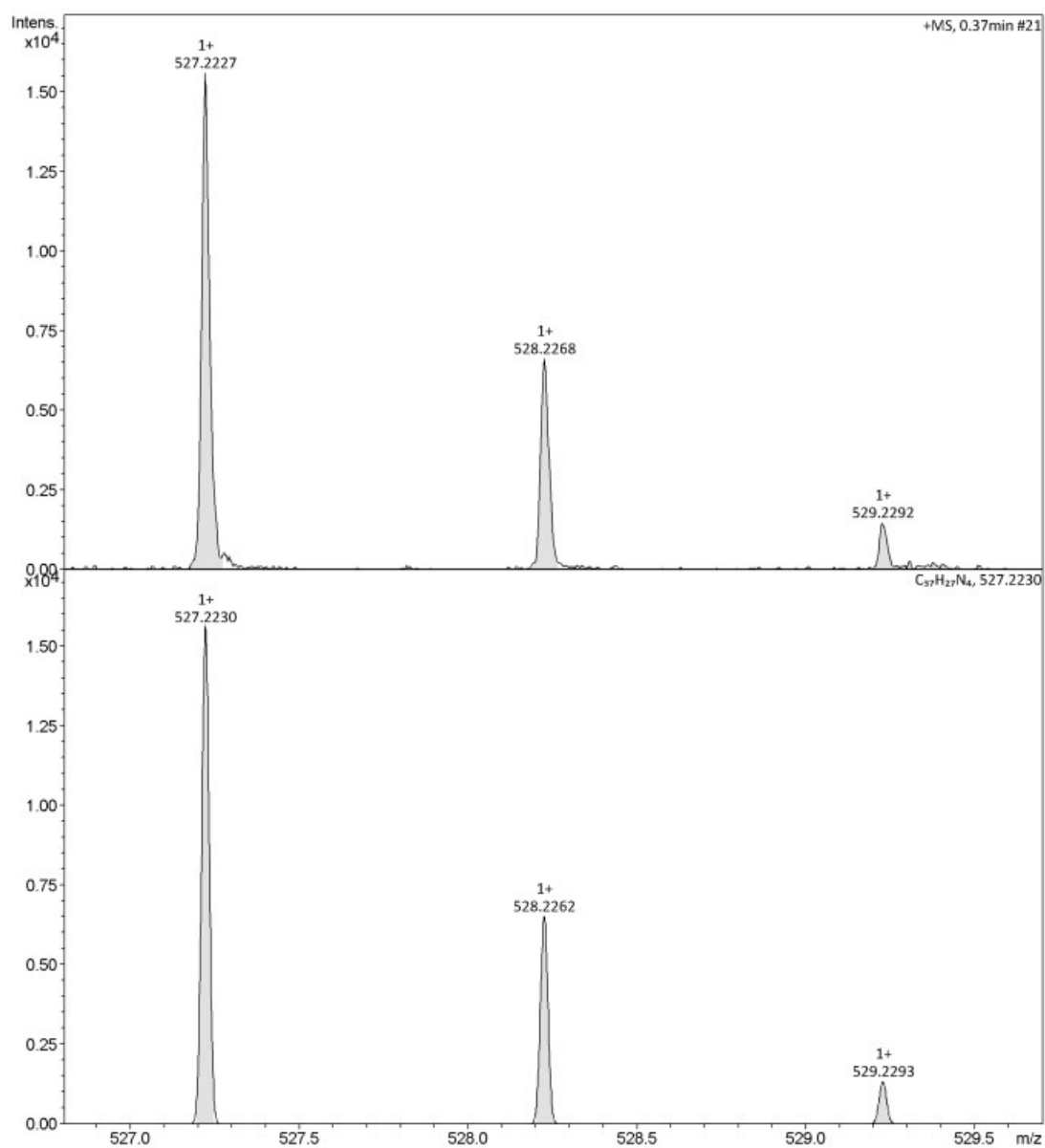


Fig. S12 ESI-HRMS spectrum of F<sub>0</sub>C.

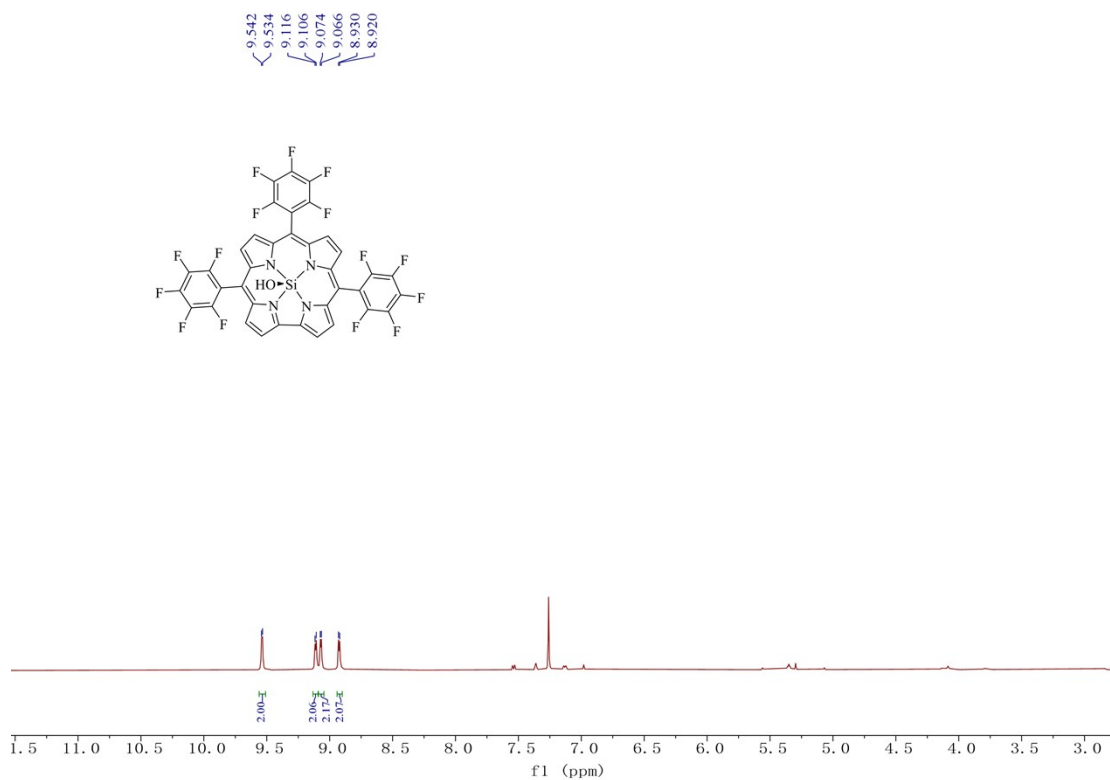


Fig. S13  $^1H$  NMR spectrum of  $F_{15}C-Si$ .

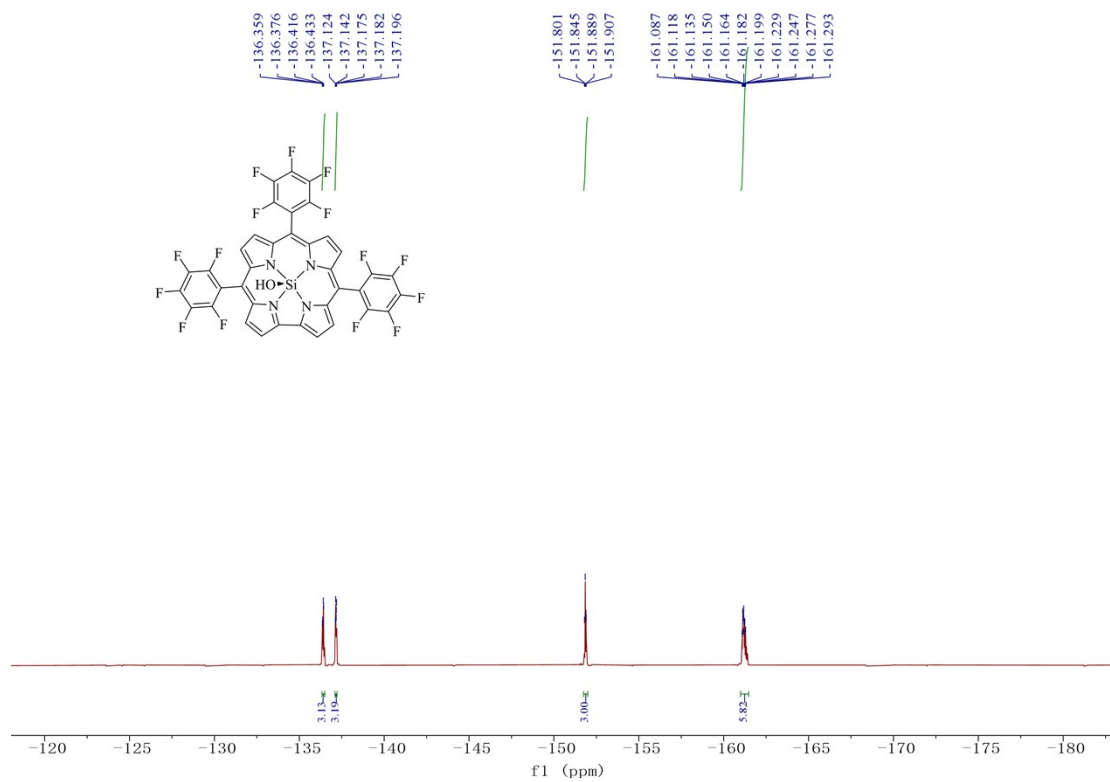
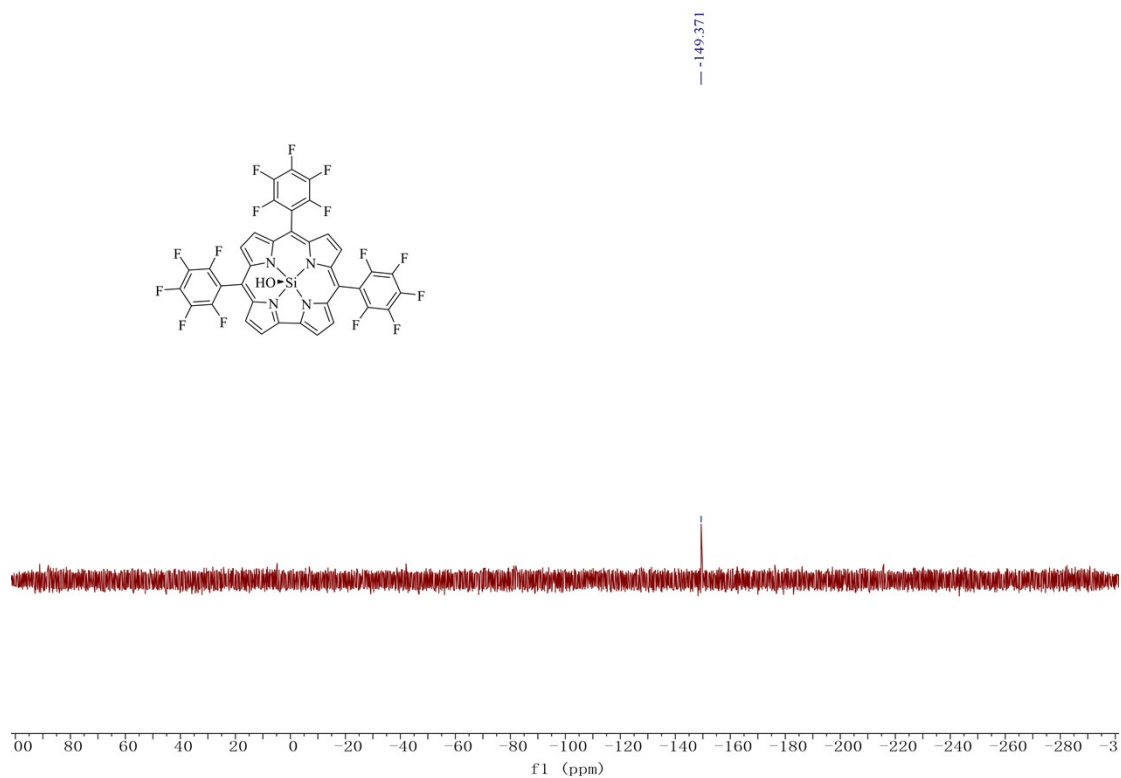


Fig. S14  $^{19}F$  NMR spectrum of  $F_{15}C-Si$ .



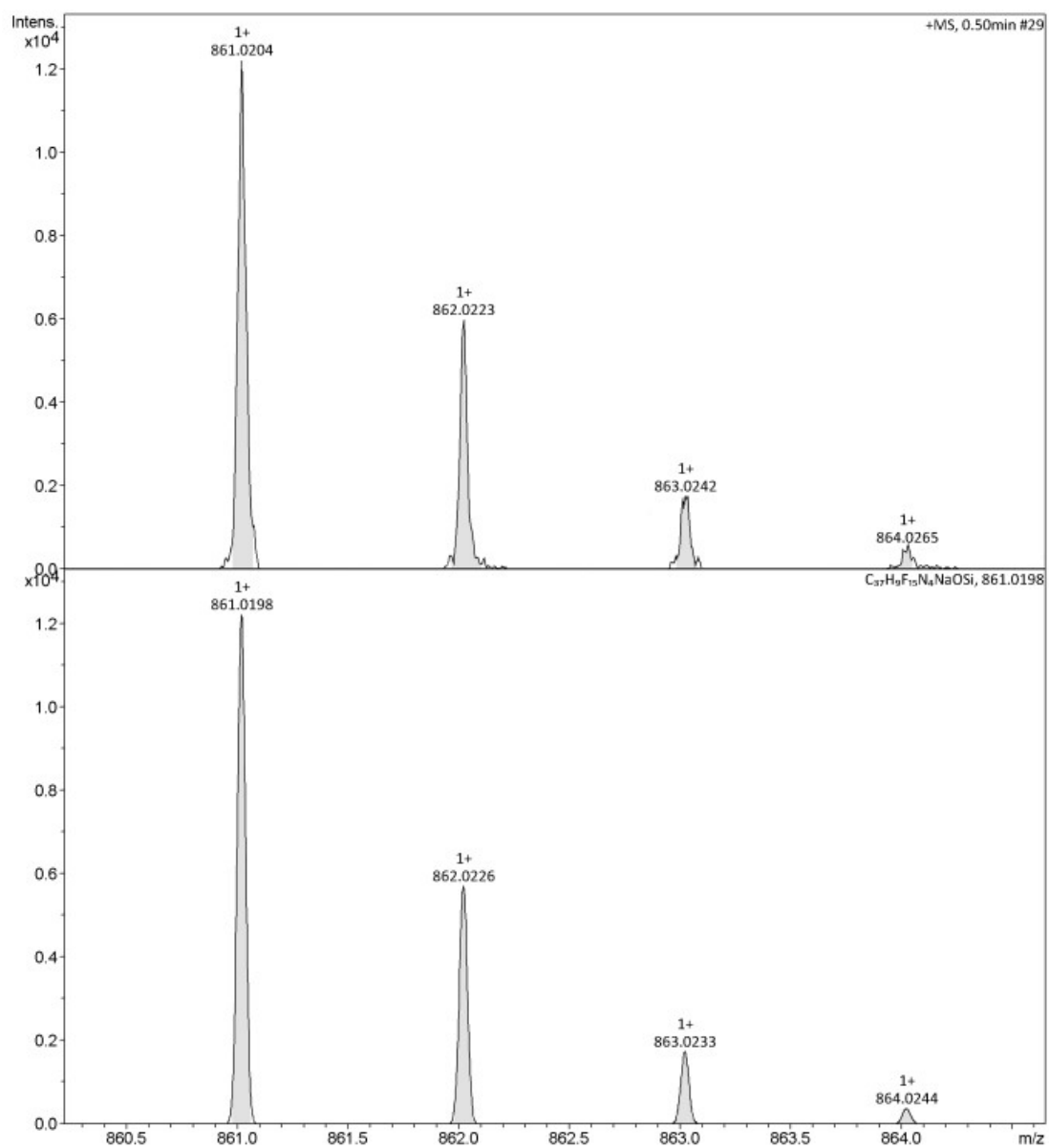
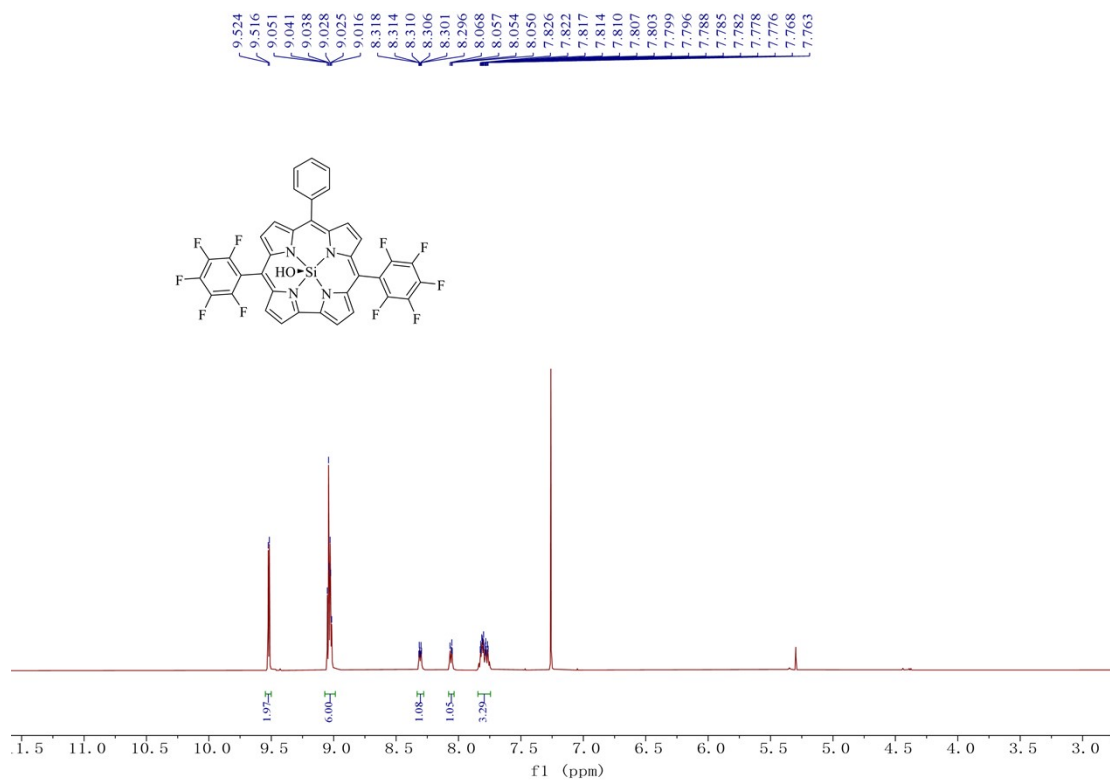
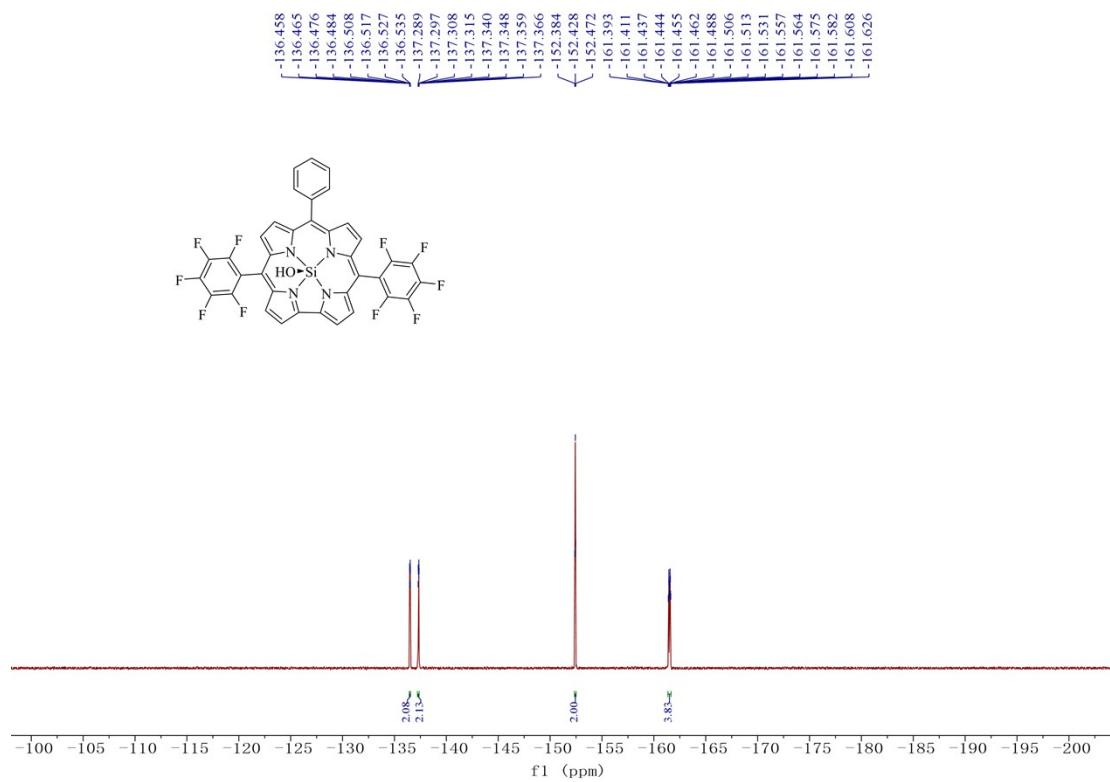


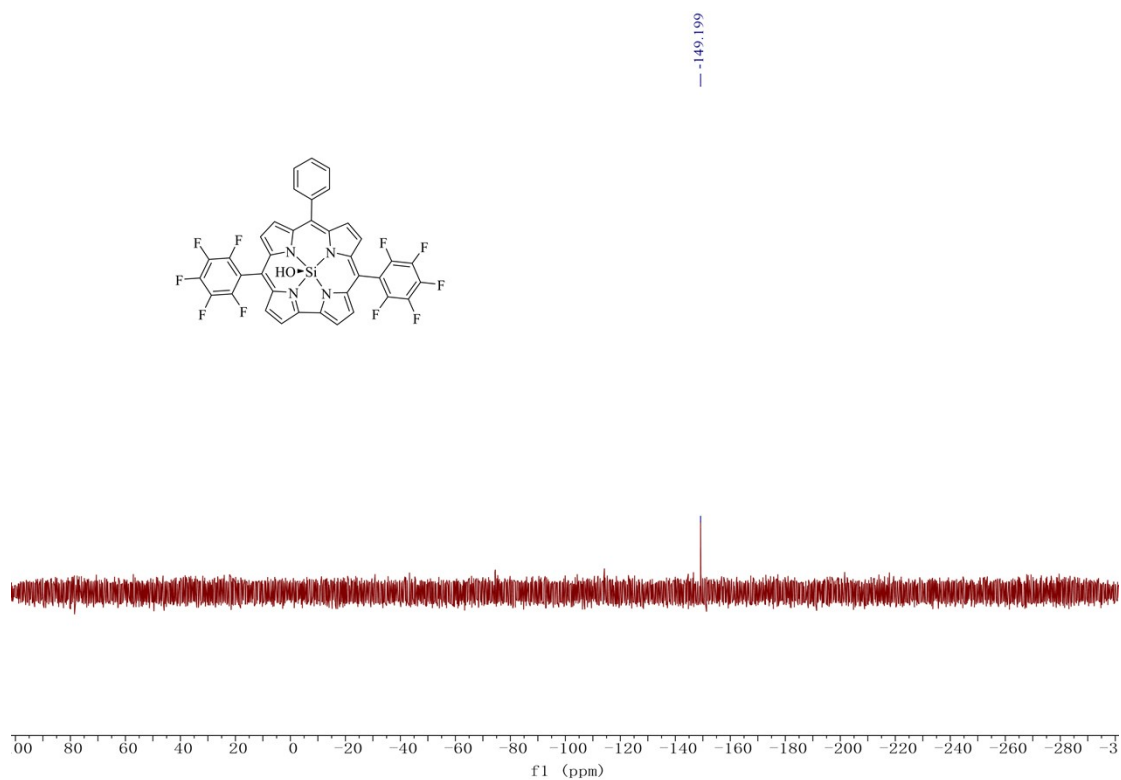
Fig. S16 ESI-HRMS spectrum of F<sub>15</sub>C-Si.



**Fig. S17** <sup>1</sup>H NMR spectrum of F<sub>10</sub>C-Si.



**Fig. S18** <sup>19</sup>F NMR spectrum of F<sub>10</sub>C-Si.



**Fig. S19**  $^{29}Si$  NMR spectrum of  $F_{10}C-Si$ .

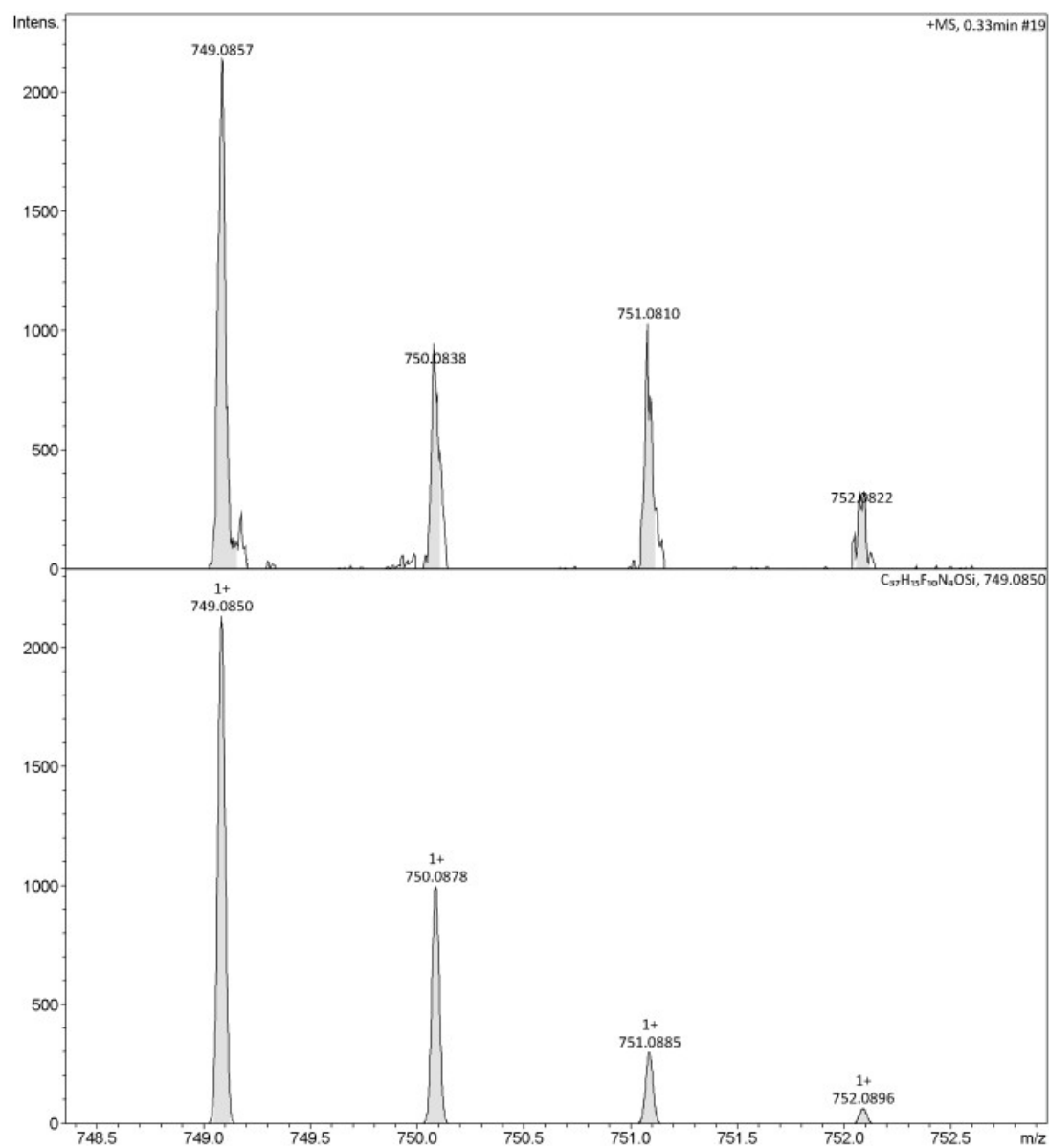
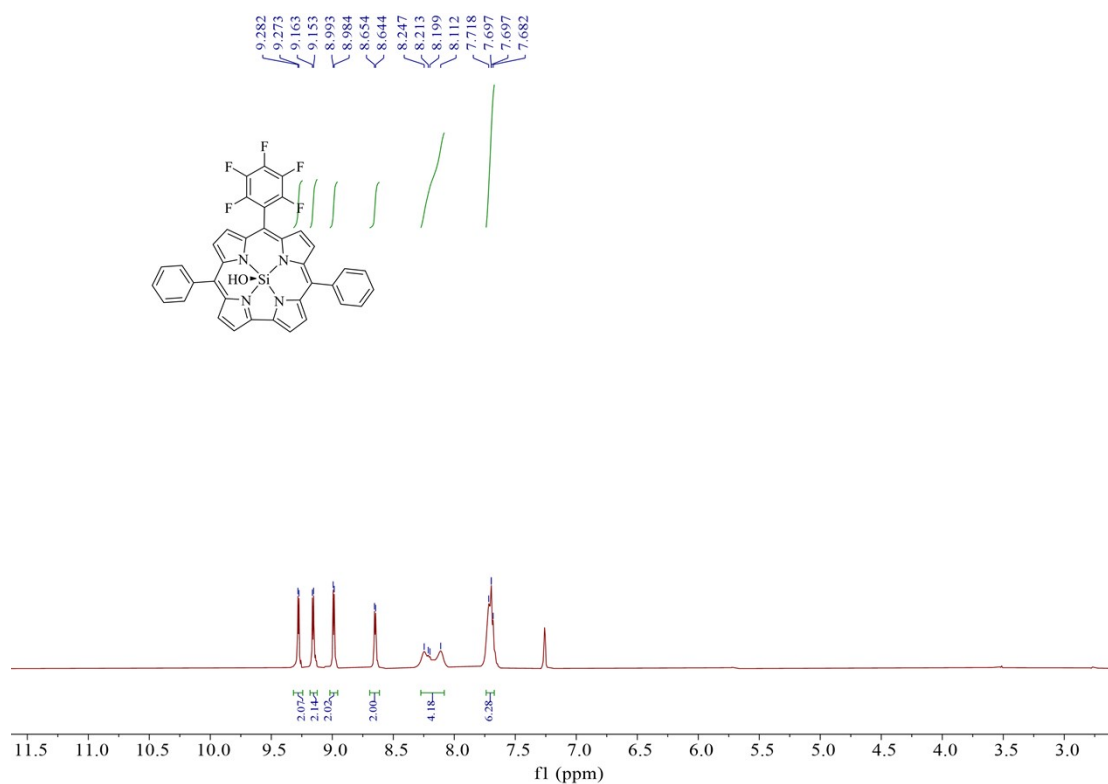
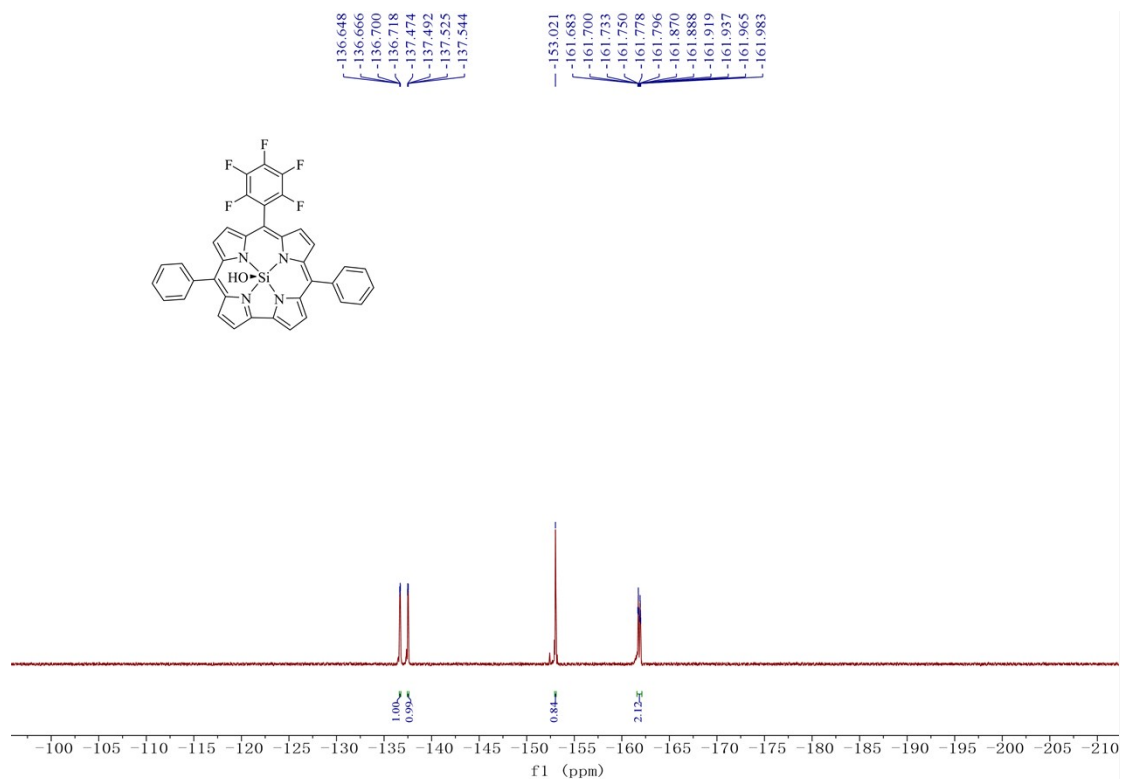


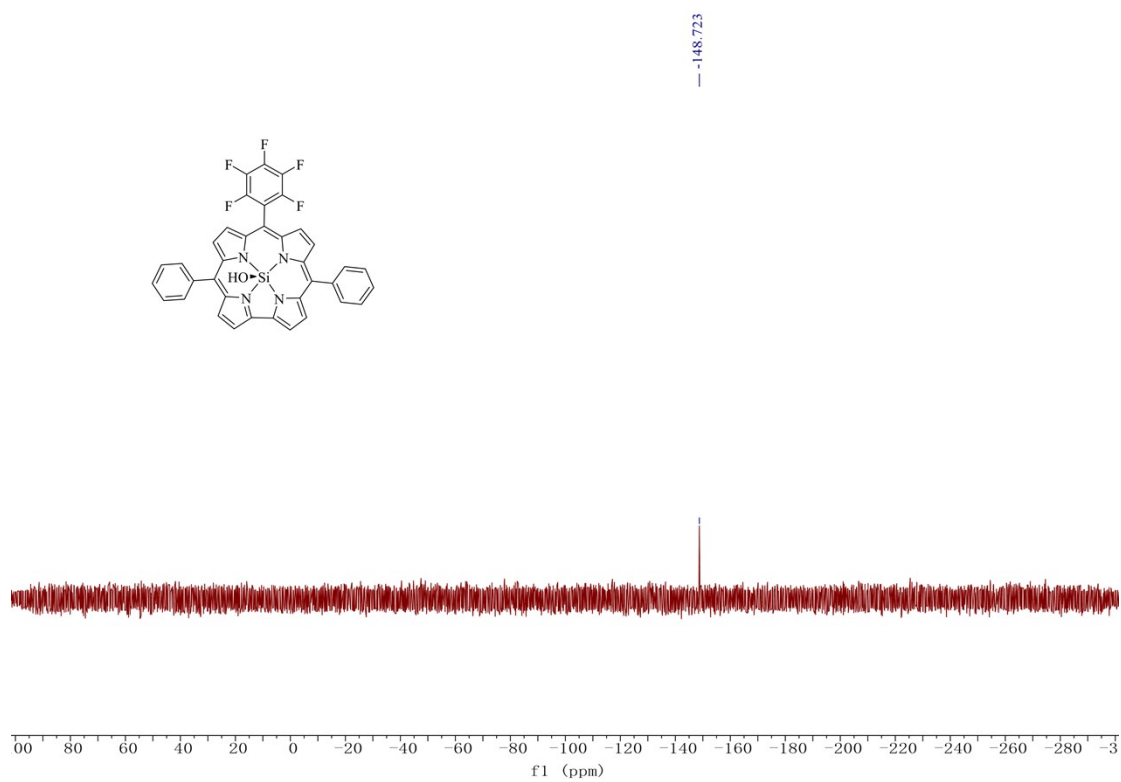
Fig. S20 ESI-HRMS spectrum of F<sub>10</sub>C-Si.



**Fig. S21 <sup>1</sup>H NMR spectrum of F<sub>5</sub>C-Si.**



**Fig. S22 <sup>19</sup>F NMR spectrum of F<sub>5</sub>C-Si.**



**Fig. S23** <sup>29</sup>Si NMR spectrum of F<sub>5</sub>C-Si.

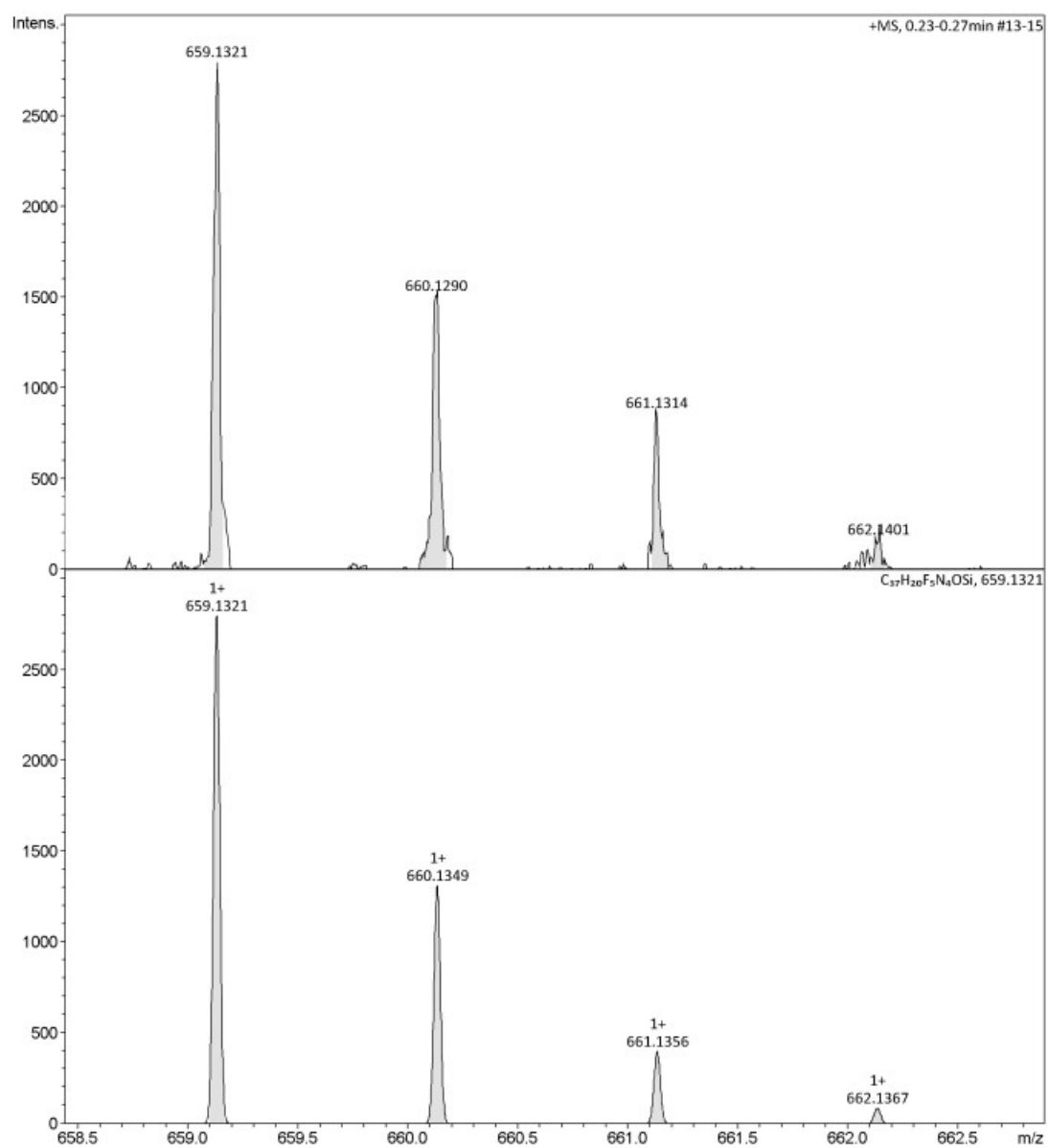
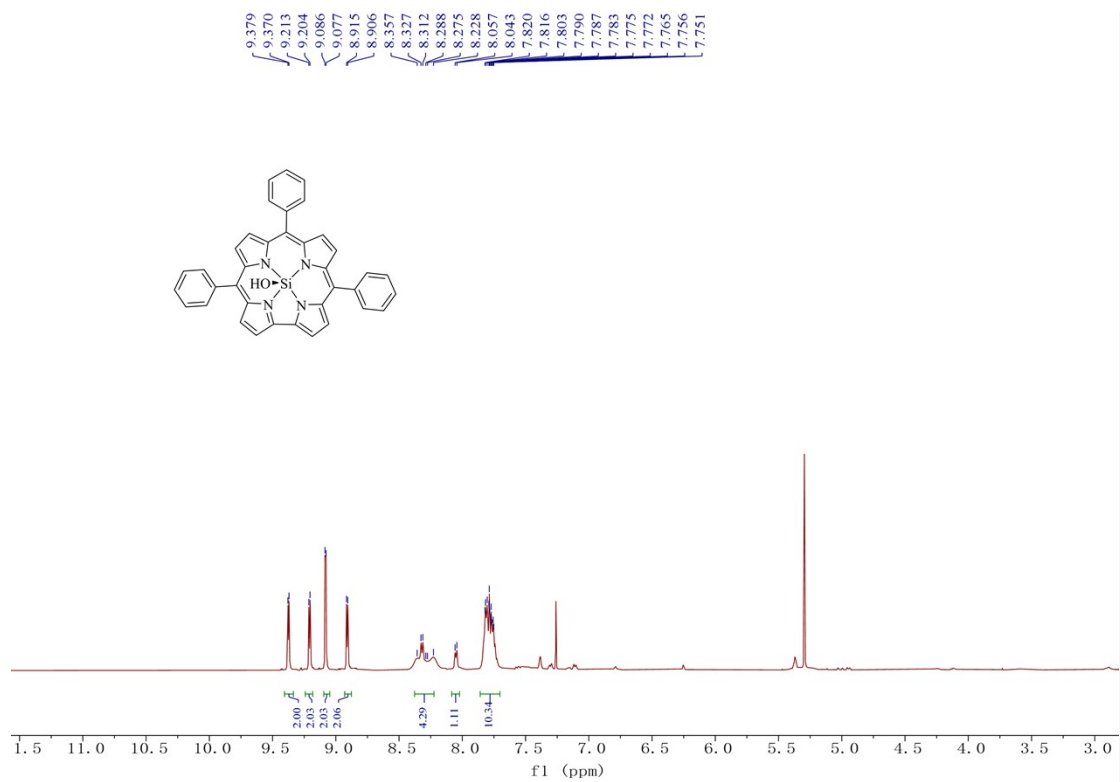
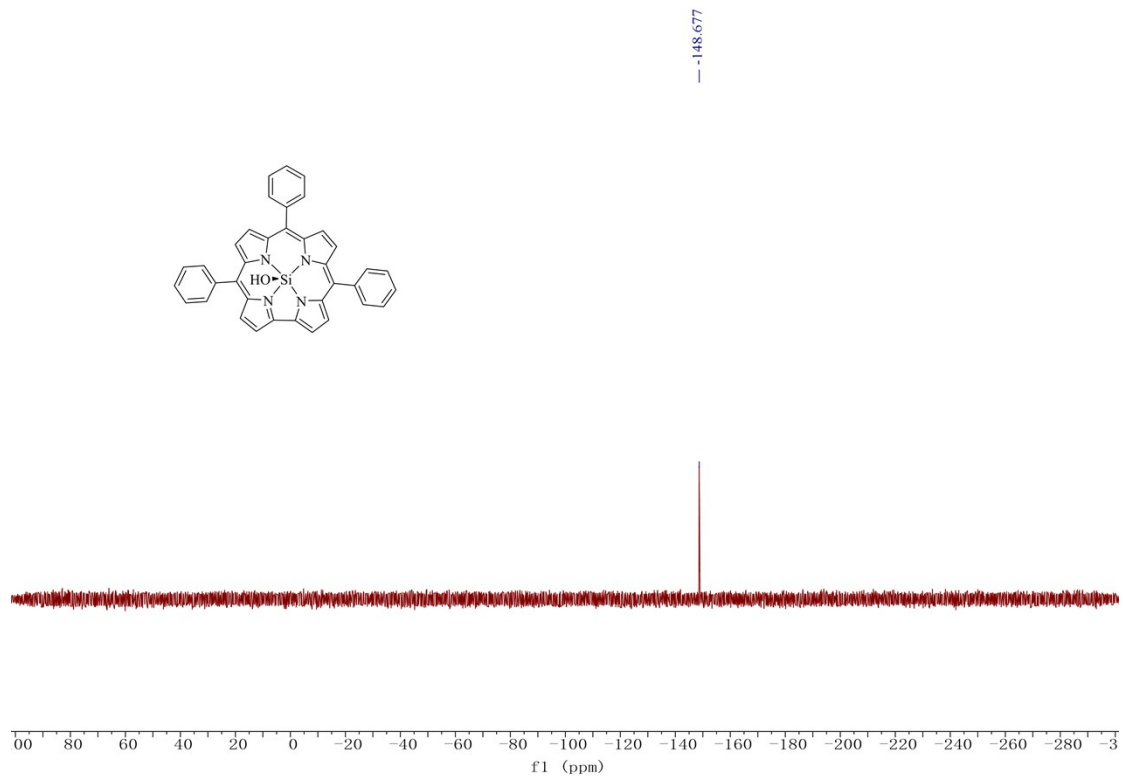


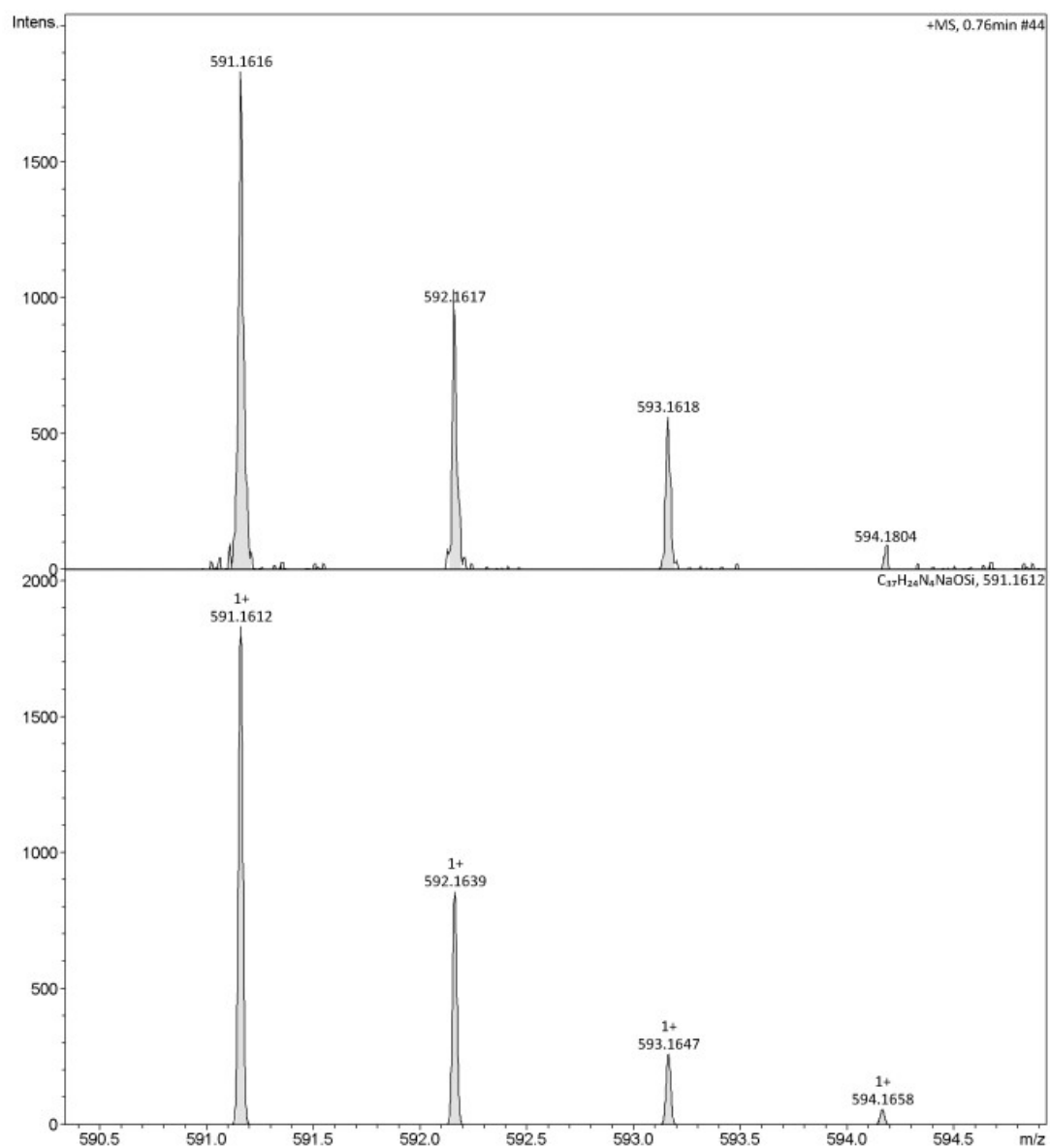
Fig. S24 ESI-HRMS spectrum of  $\text{F}_3\text{C-Si}$ .



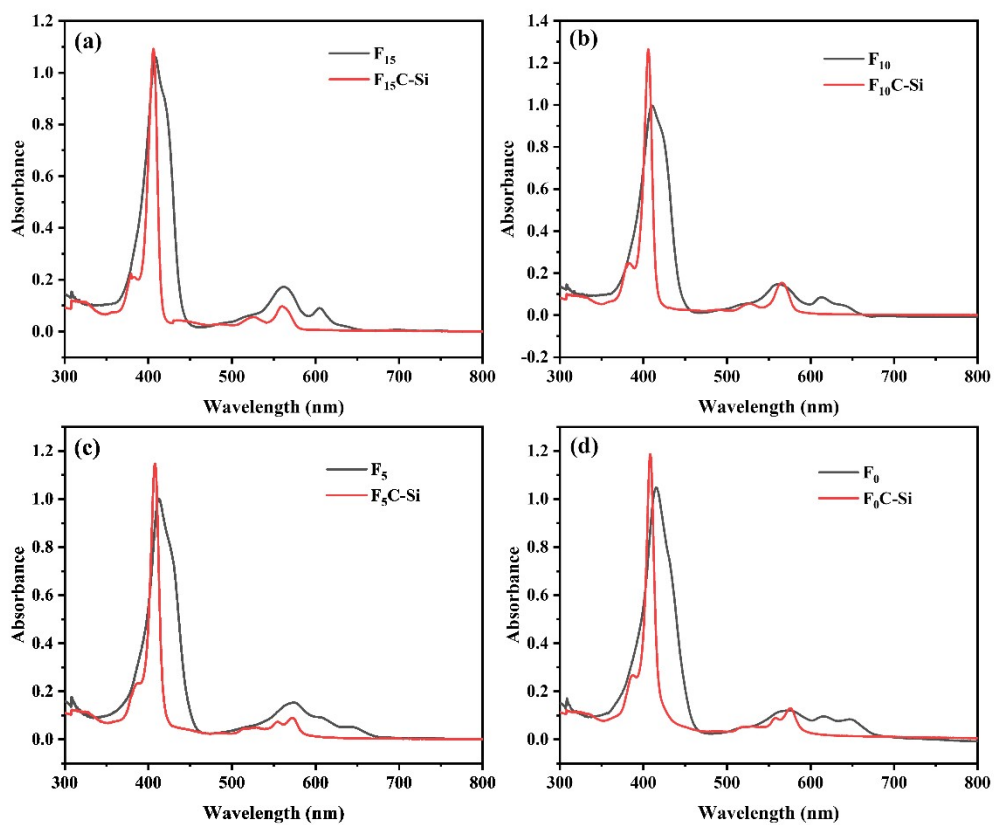
**Fig. S25** <sup>1</sup>H NMR spectrum of F<sub>0</sub>C-Si.



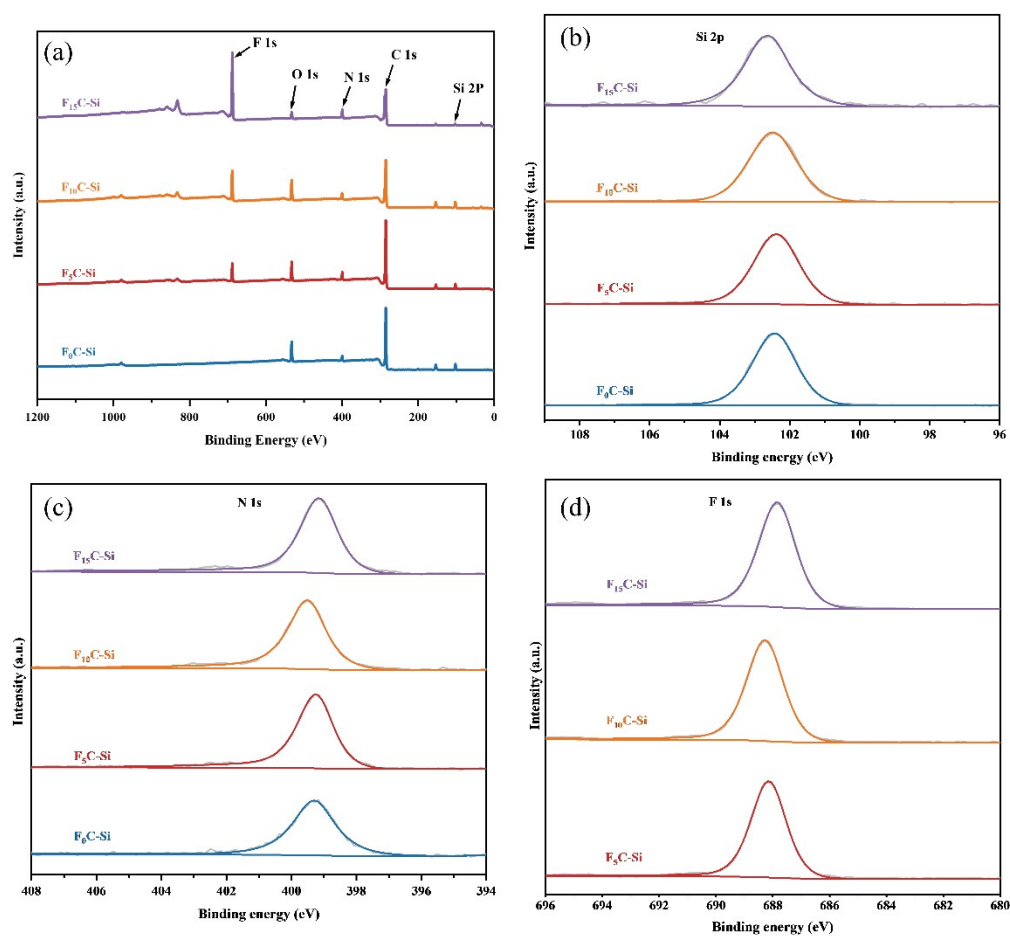
**Fig. S26** <sup>29</sup>Si NMR spectrum of F<sub>0</sub>C-Si.



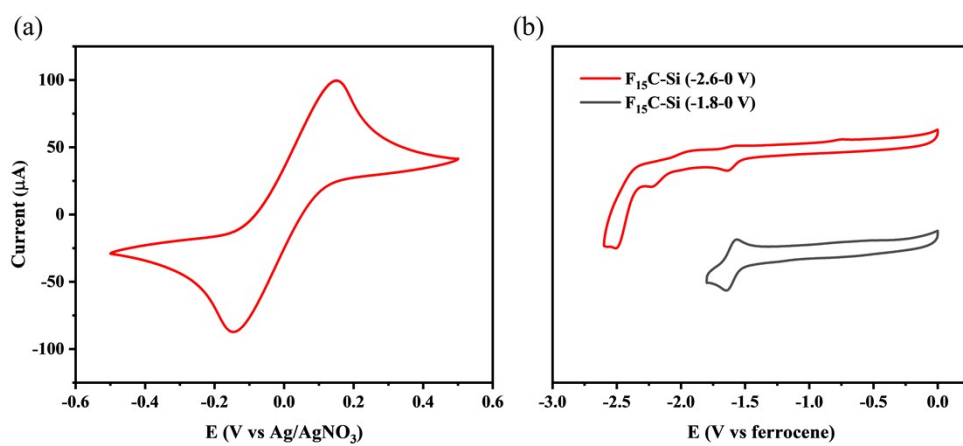
**Fig. S27** ESI-HRMS spectrum of F<sub>0</sub>C-Si.



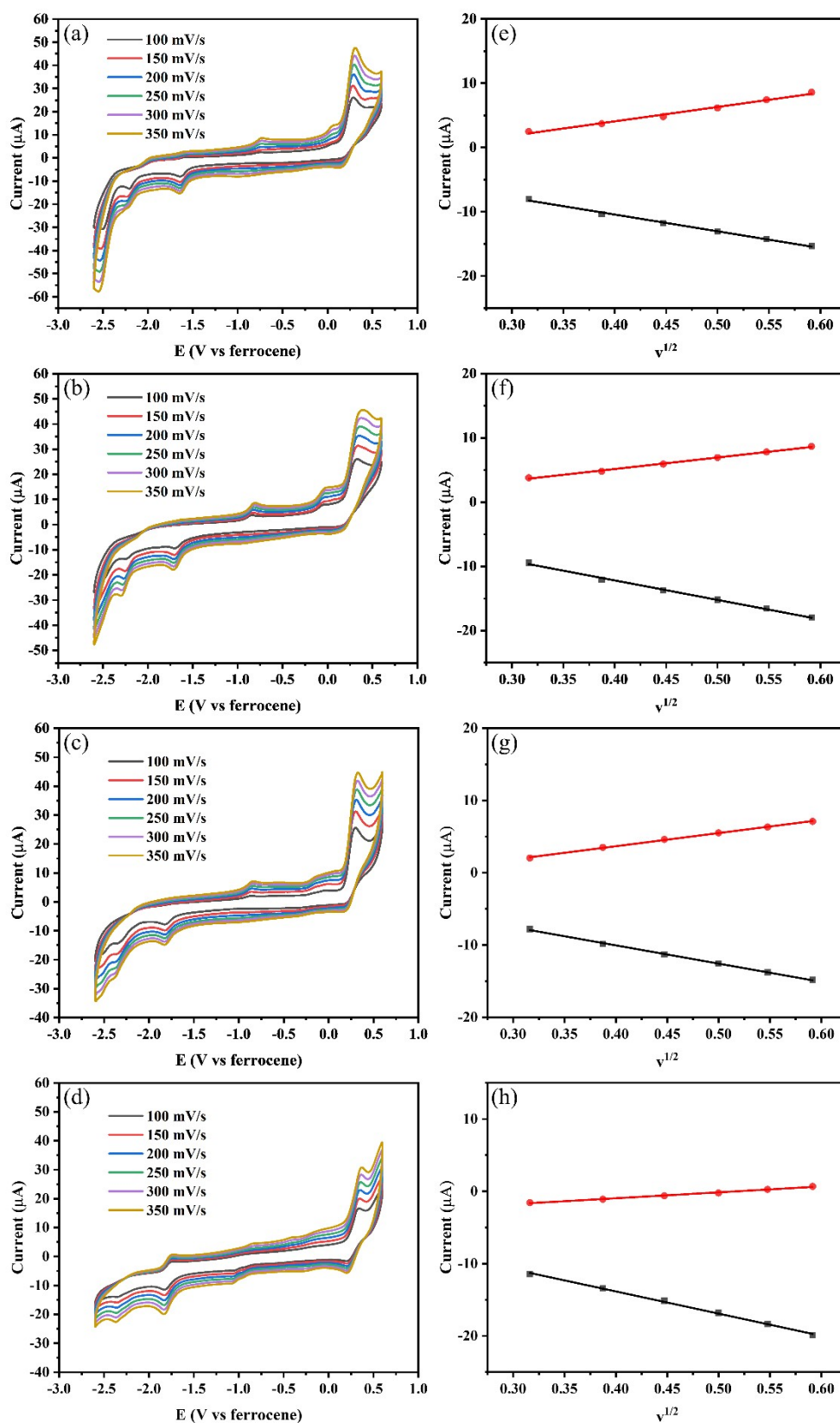
**Fig. S28** UV-vis spectra of  $F_{15}C$  and  $F_{15}C-Si$  (a),  $F_{10}C$  and  $F_{10}C-Si$  (b),  $F_5C$  and  $F_5C-Si$  (c),  $F_0C$  and  $F_0C-Si$  (d) in  $CH_2Cl_2$  solvent at room temperature.



**Fig. S29** XPS survey scan spectra of  $F_{15}C-Si$ ,  $F_{10}C-Si$ ,  $F_5C-Si$  and  $F_0C-Si$  and high-resolution XPS of characteristic element, a) full spectrum b) Si 2p c) N 1s d) F 1s.



**Fig. S30** (a) The redox couple of ferrocene in DMF containing 0.10 M TBAP with blank glassy carbon as the working electrode; (b) CVs of  $F_{15}C-Si$  in the range of -2.6 - 0 V and -1.8 - 0 V in  $N_2$ -saturated DMF containing 0.10 M TBAP.



**Fig. S31** CVs of 0.5 mM (a)  $F_{15}C-Si$ , (b)  $F_{10}C-Si$ , (c)  $F_5C-Si$  and (d)  $F_0C-Si$  with a varying scan rate ( $\nu$ ) from 50 mV/s to 350 mV/s using the glassy carbon as the working electrode and plots of the maximum current ( $i_p$ ) for the reduction and oxidation waves vs. the scan rate ( $\nu^{1/2}$ ) (e-h).

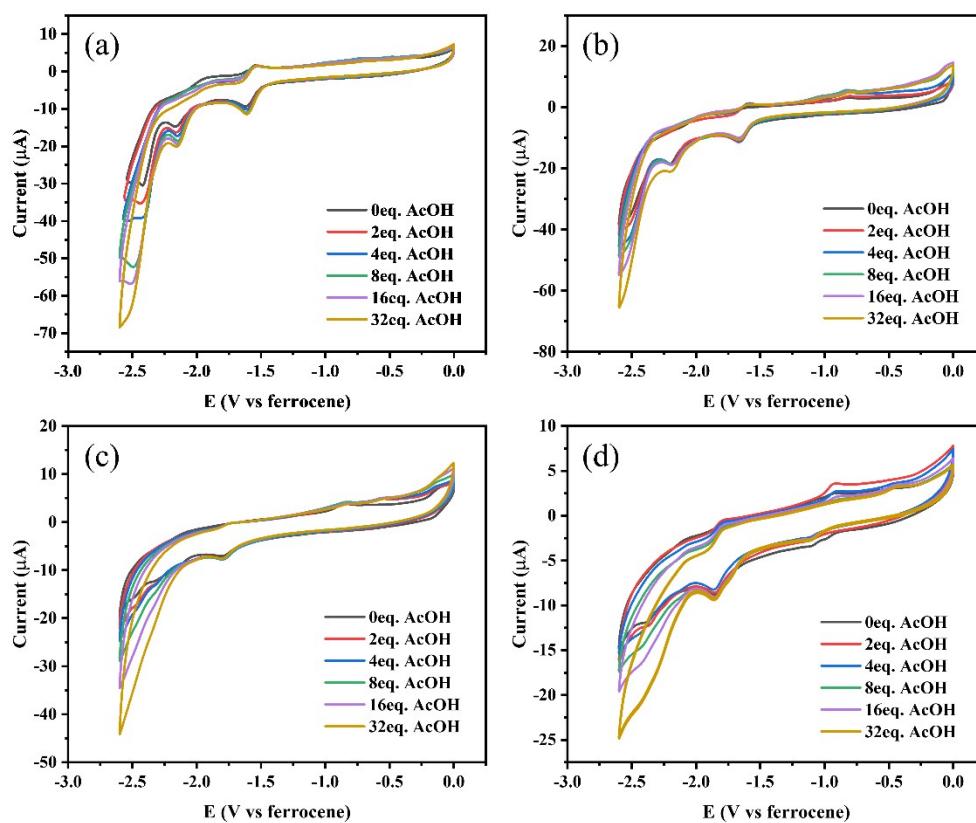


Fig. S32 CVs of 0.5 mM silicon corrole complexes ( $F_{15}C-Si$  to  $F_0C-Si$ ) (a-d) with increasing amounts of AcOH from 0 to 32 equivalents in  $N_2$ -saturated DMF containing 0.1 M TBAP.

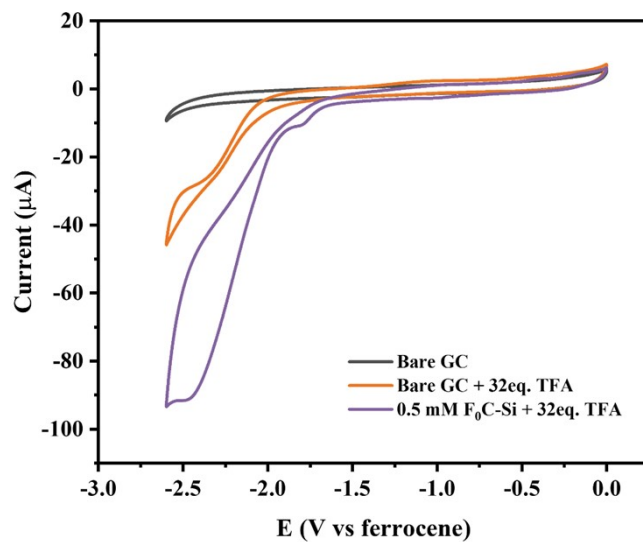


Fig. S33 CVs of bare glassy carbon electrode and 0.5 mM  $F_0C-Si$  in DMF containing 0.1 M TBAP with 32 equivalents TFA.

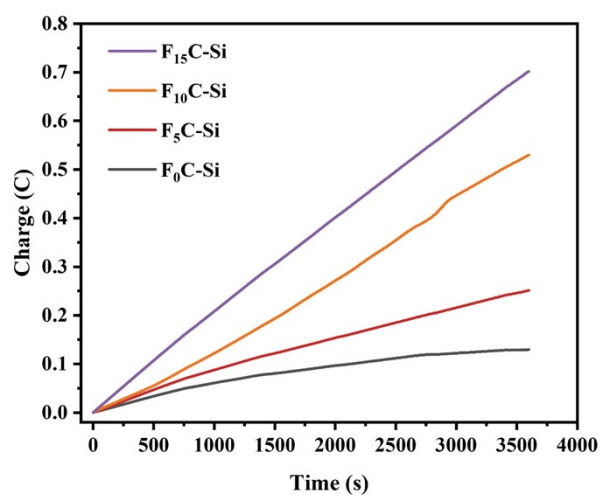


Fig. S34 Charge of 0.5 mM F<sub>15</sub>C-Si, F<sub>10</sub>C-Si, F<sub>5</sub>C-Si and F<sub>0</sub>C-Si after 1 h of electrolysis in DMF containing 0.1 M TBAP with 32 equivalents TFA.

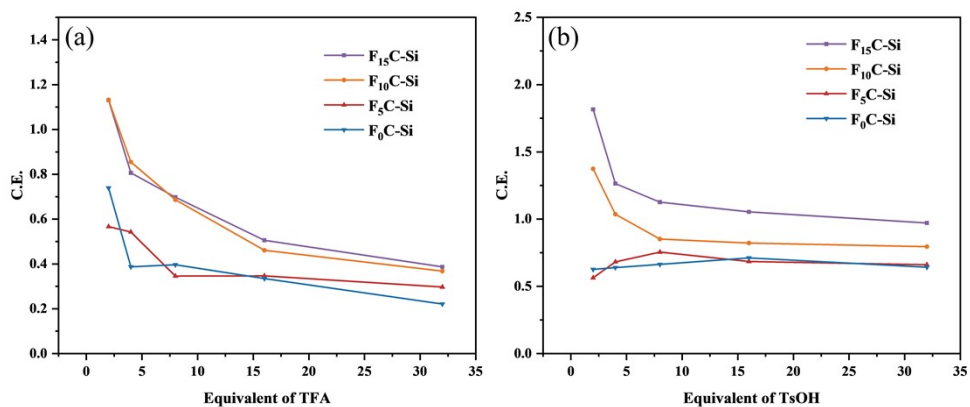


Fig. S35 The variation of C.E. for F<sub>15</sub>C-Si, F<sub>10</sub>C-Si, F<sub>5</sub>C-Si and F<sub>0</sub>C-Si under different concentrations of proton sources: a) TFA; b) TsOH.

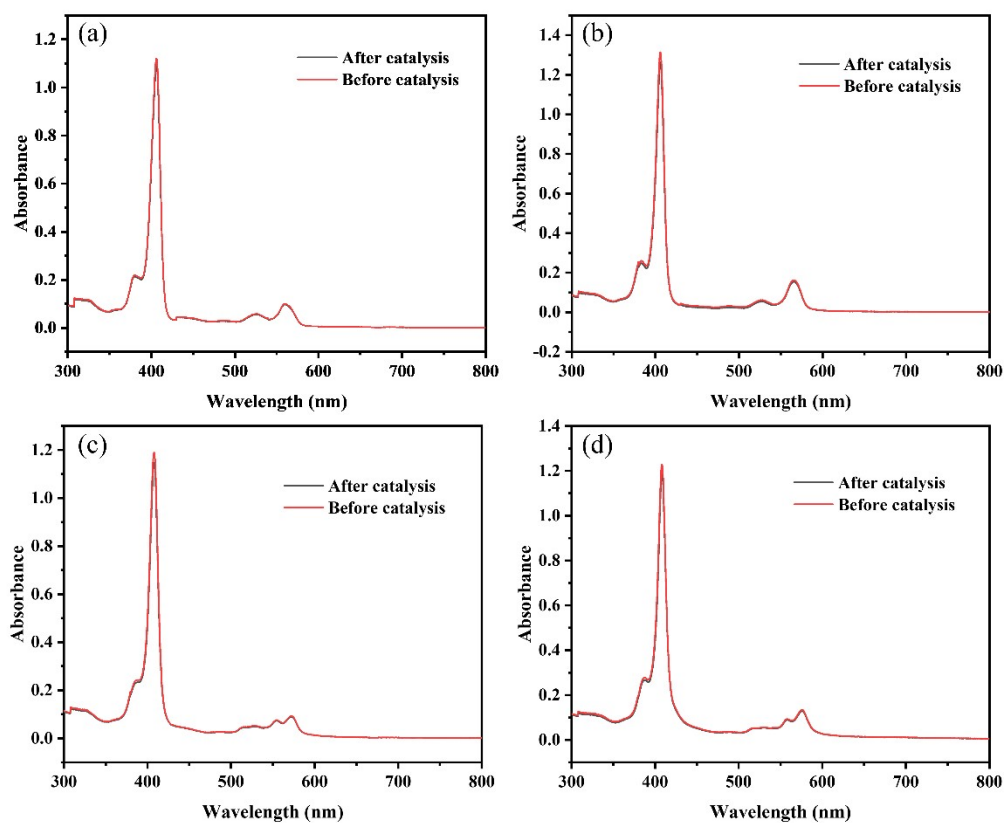


Fig. S36 UV-vis spectra of 0.5 mM  $F_{15}C-Si$ ,  $F_{10}C-Si$ ,  $F_5C-Si$  and  $F_0C-Si$  in DMF containing 0.1 M TBAP with 32 equivalents TFA and after 1 h electrolysis.

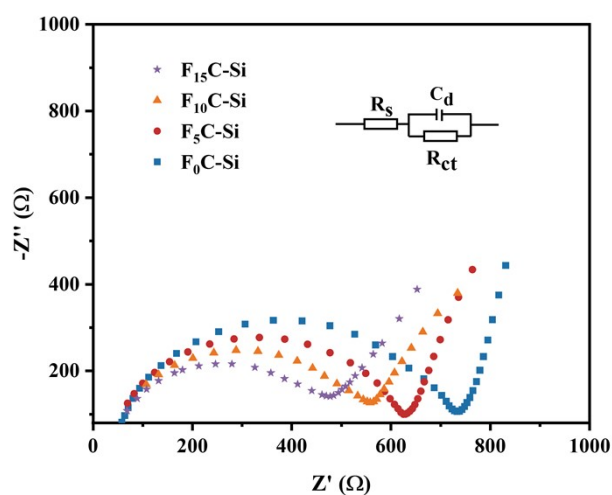


Fig. S37 The impedance plots of 0.5 mM  $F_{15}C-Si$ ,  $F_{10}C-Si$ ,  $F_5C-Si$  and  $F_0C-Si$  after one hour of electrolysis in DMF containing 0.1 M TBAP with the addition of 32 equivalents of TFA.

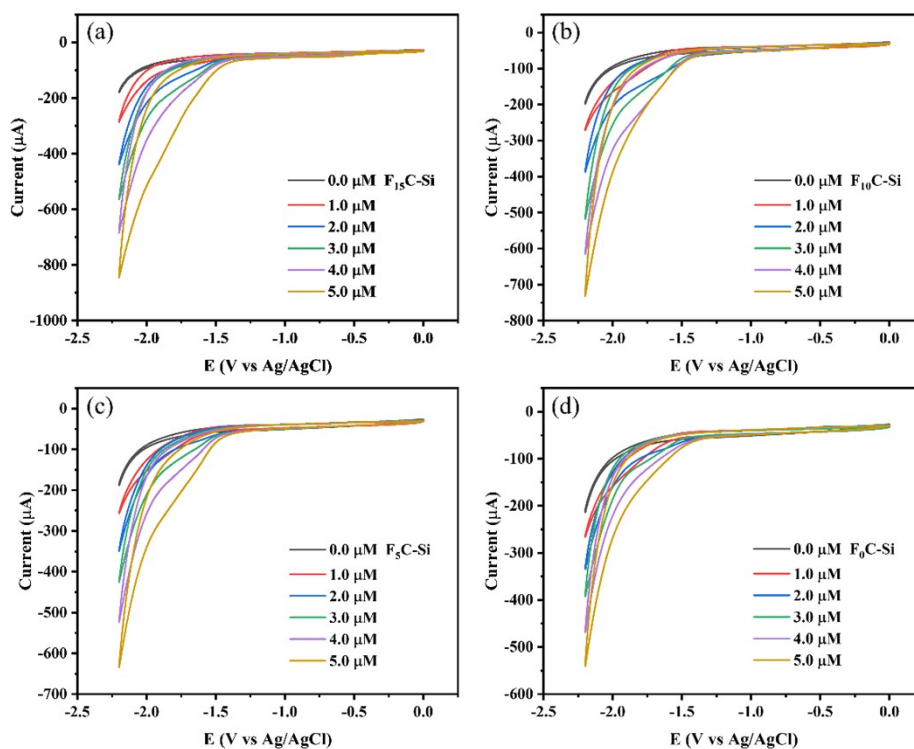


Fig. S38 CVs of various concentrations of  $F_{15}C-Si$ ,  $F_{10}C-Si$ ,  $F_5C-Si$  and  $F_0C-Si$  (0.0  $\mu M$ –5.0  $\mu M$ ) in buffer solutions at pH=7.0 ( $V_{MeCN}/V_{H_2O} = 2/3$ ).

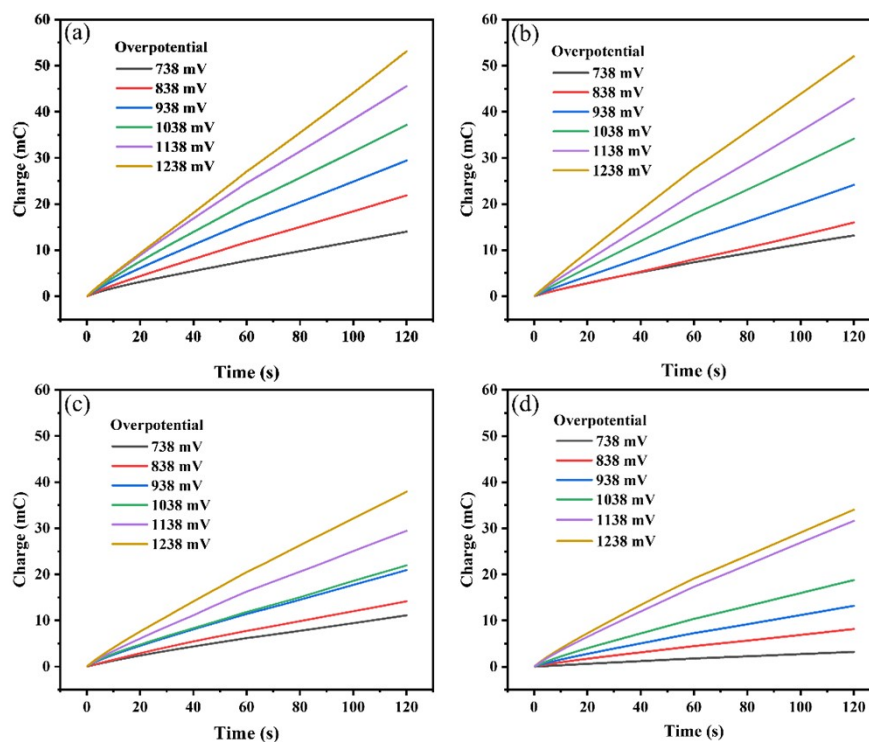


Fig. S39 Charge accumulation of electrolyzing 5  $\mu M$   $F_{15}C-Si$ ,  $F_{10}C-Si$ ,  $F_5C-Si$  and  $F_0C-Si$  at a range of overpotentials in buffer solutions at pH=7.0 for 2 minutes (a-d).

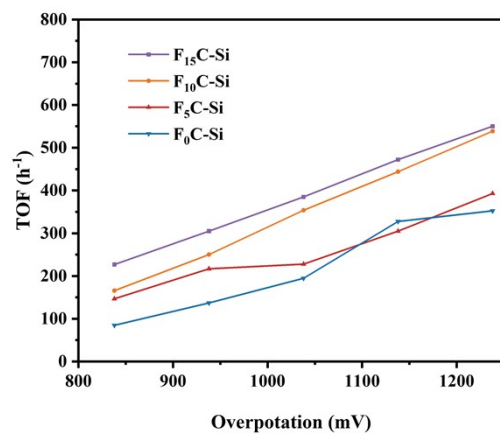


Fig. S40 TOF values of 5  $\mu$ M F<sub>15</sub>C-Si, F<sub>10</sub>C-Si, F<sub>5</sub>C-Si and F<sub>0</sub>C-Si at different overpotentials in buffer solutions at pH=7.0.

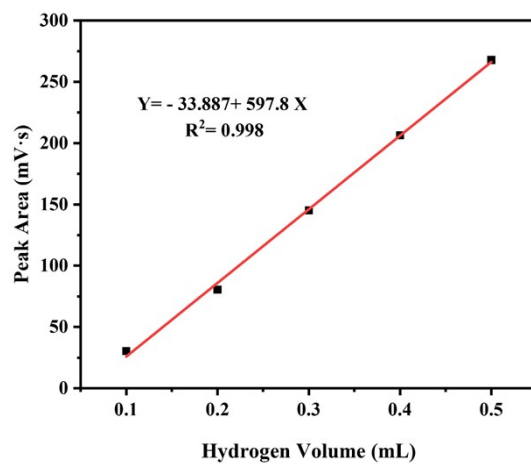


Fig. S41 The hydrogen calibration plot from GC measurements.

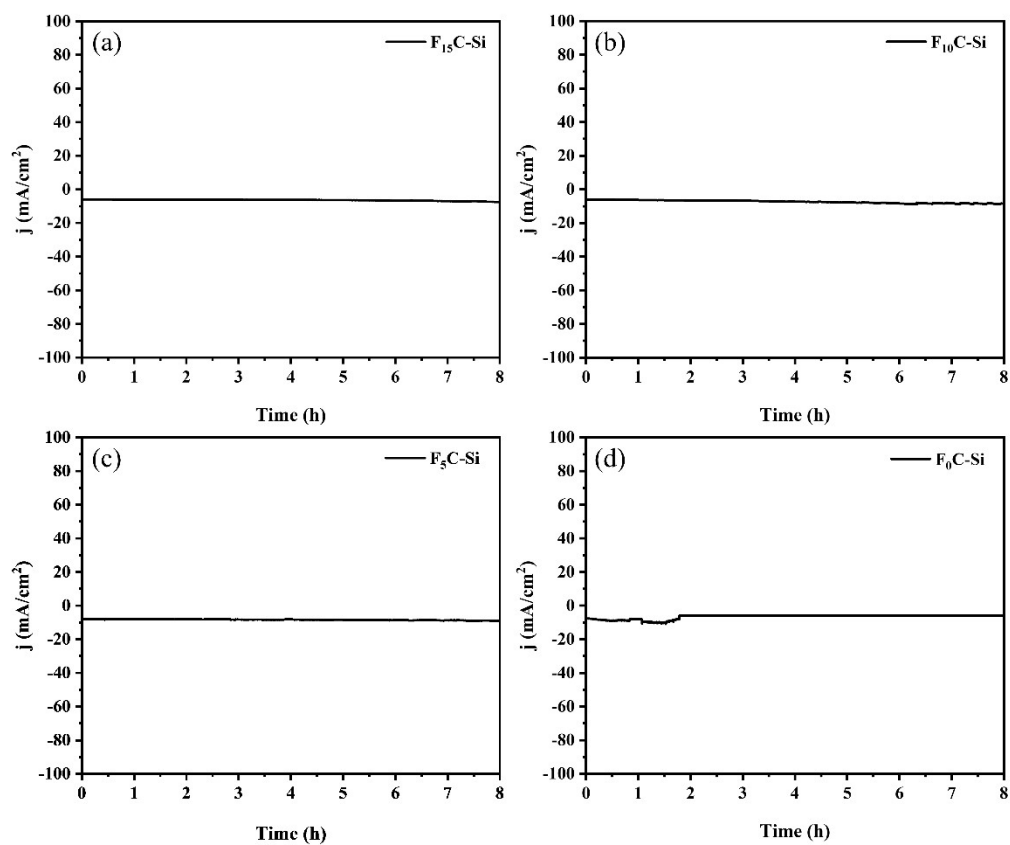
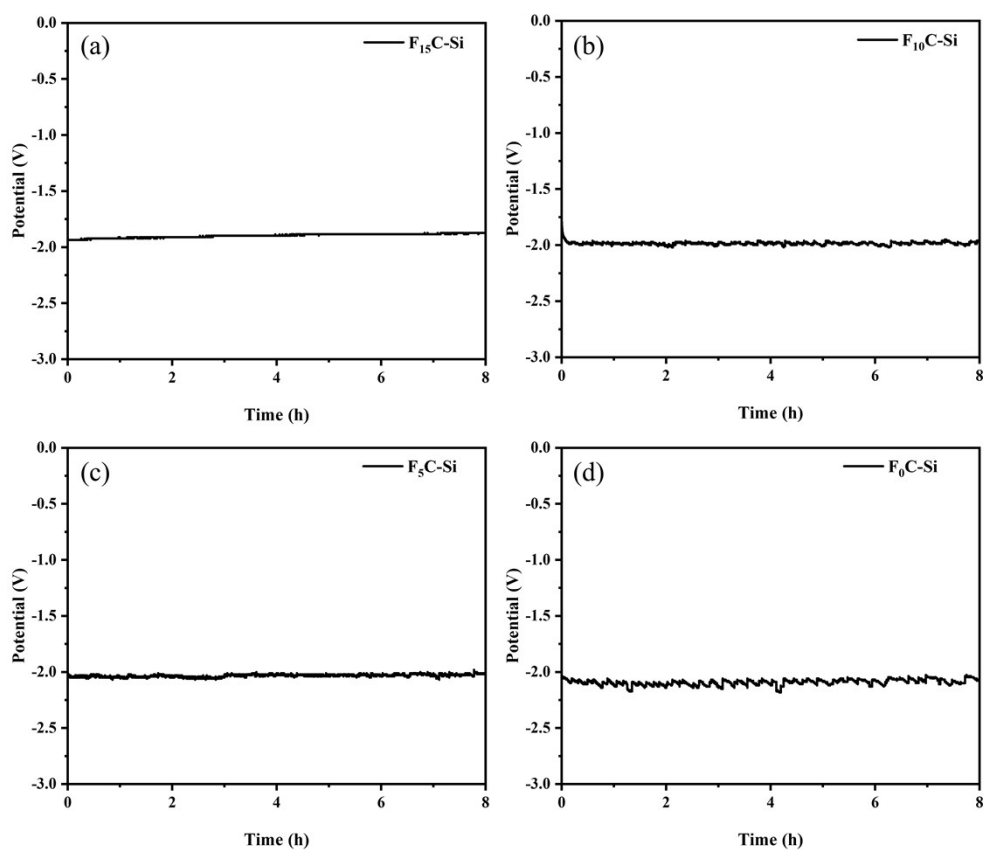
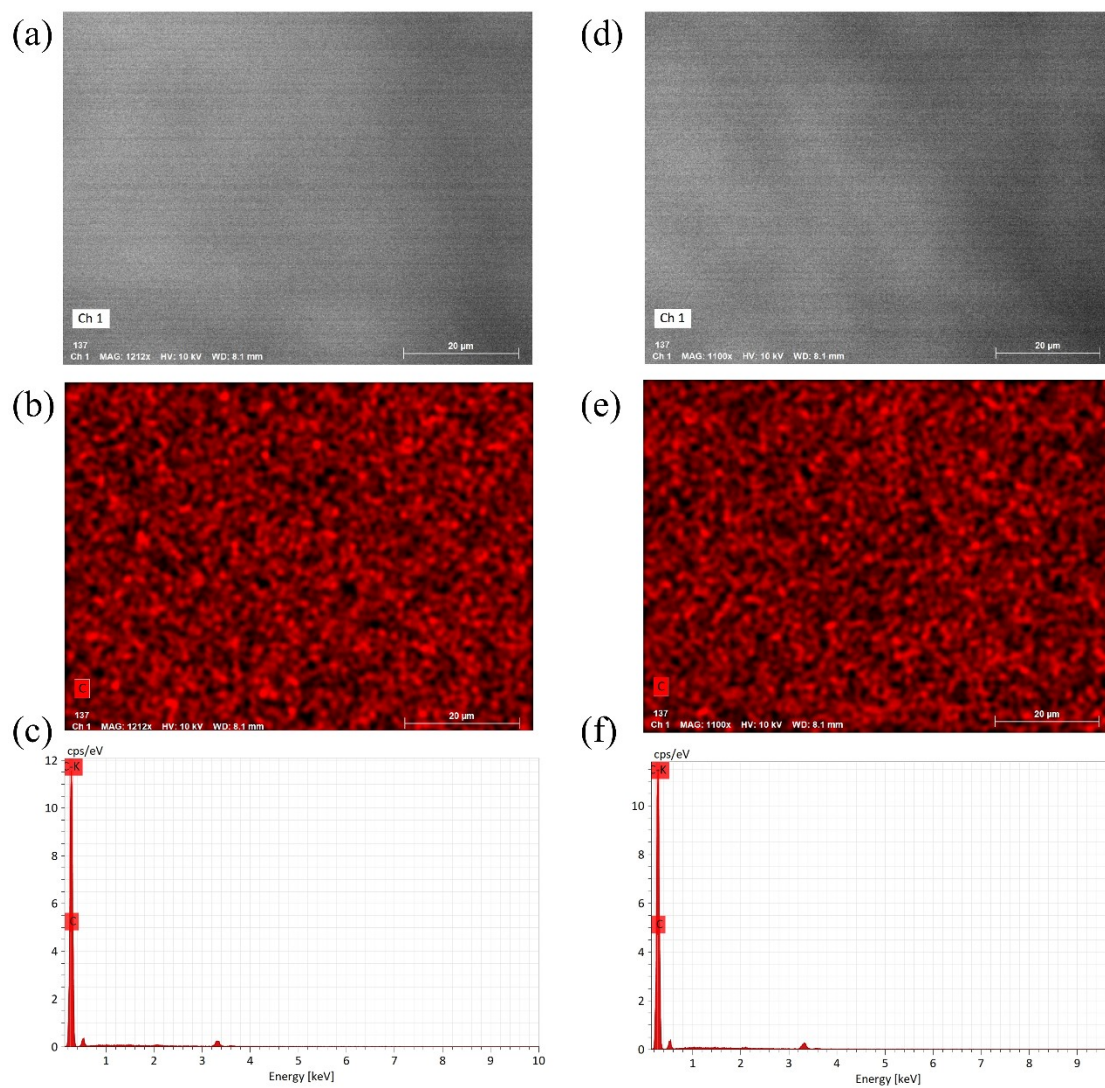


Fig. S42 Current versus 5  $\mu$ M  $F_{15}C-Si$ ,  $F_{10}C-Si$ ,  $F_5C-Si$  and  $F_0C-Si$  in buffer solution at pH = 7.0 at -2.2 V for 8 h electrolysis.



**Fig. S43** Voltage variation versus 5  $\mu M$   $F_{15}C-Si$ ,  $F_{10}C-Si$ ,  $F_5C-Si$ , and  $F_0C-Si$  in buffer solution at pH = 7.0 under constant current electrolysis at 400  $\mu A$  for 8 h.



**Fig. S44** SEM images and EDX data of GC electrodes before (a-c) and after (d-f) electrolysis.

**Table S1** Performance parameters of four corroles F<sub>15</sub>C-Si, F<sub>10</sub>C-Si, F<sub>5</sub>C-Si and F<sub>0</sub>C-Si in DMF containing 16 mM TFA

| complex              | $i_{cat}/i_p$ | Overpotential, mV | TOFmax, s <sup>-1</sup> | C.E  |
|----------------------|---------------|-------------------|-------------------------|------|
| F <sub>15</sub> C-Si | 12.38         | 973               | 173.19                  | 0.39 |
| F <sub>10</sub> C-Si | 11.77         | 1004              | 125.56                  | 0.37 |
| F <sub>5</sub> C-Si  | 9.50          | 1047              | 97.62                   | 0.30 |
| F <sub>0</sub> C-Si  | 7.07          | 1061              | 85.41                   | 0.22 |

**Table S2** Performance parameters of four corroles F<sub>15</sub>C-Si, F<sub>10</sub>C-Si, F<sub>5</sub>C-Si and F<sub>0</sub>C-Si in DMF containing 16 mM TsOH

| complex              | $i_{cat}/i_p$ | Overpotential, mV | TOFmax, s <sup>-1</sup> | C.E  |
|----------------------|---------------|-------------------|-------------------------|------|
| F <sub>15</sub> C-Si | 31.08         | 1135              | 752.65                  | 0.97 |
| F <sub>10</sub> C-Si | 25.43         | 1141              | 614.02                  | 0.79 |
| F <sub>5</sub> C-Si  | 21.14         | 1199              | 531.67                  | 0.66 |
| F <sub>0</sub> C-Si  | 20.55         | 1216              | 397.28                  | 0.64 |

**Table S3** The turnover frequency (TOF) of silicon corroles and transition metal complexes in aqueous phase.

| complex                          | TOF(h <sup>-1</sup> ) | Overpotential, mV | Solution | Reference |
|----------------------------------|-----------------------|-------------------|----------|-----------|
| F <sub>15</sub> C-Si             | 550.26                | 1238              | Buffer   | This work |
| F <sub>10</sub> C-Si             | 538.86                | 1238              | Buffer   | This work |
| F <sub>5</sub> C-Si              | 392.95                | 1238              | Buffer   | This work |
| F <sub>0</sub> C-Si              | 327.56                | 1238              | Buffer   | This work |
| BPTC-Co                          | 567                   | 1088              | Buffer   | 5         |
| PFIC-Co                          | 405                   | 1038              | Buffer   | 6         |
| Fe(TPFC)Cl                       | 274                   | 838               | Water    | 7         |
| BPXSC-Co                         | 517                   | 1138              | Buffer   | 8         |
| BPXHC-Co                         | 526                   | 1138              | Buffer   | 8         |
| Cu(HL)Cl                         | 482                   | 837               | Buffer   | 9         |
| CoOHC                            | 1447.4                | 988               | Buffer   | 10        |
| Co-BPNC-PPh <sub>3</sub>         | 450                   | 838               | Buffer   | 11        |
| (ClO <sub>4</sub> ) <sub>2</sub> | 230                   | 900               | Buffer   | 12        |

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